



How I Prepare Samples for EBSD Analysis

Matt Nowell
EBSD Product Manager
May 25, 2017

Acknowledgements

- Ron Witt – EBSD Analytical
- Stuart Wright, Rene de Kloe – EDAX
- George Vander Voort – Struers
- Lucille Giannuzzi - EXpressLO
- Joe Michael – Sandia National Lab
- Allied High Tech
- Buehler
- Gatan
- E.A. Fischione Instruments
- FEI
- JEOL
- Hysitron
- Many, many more discussions and ideas with people.....

Background

- I'm not a sample preparation expert
 - Use sample prep vendors as a resource
- I have looked at (and prepared after an initial look) a lot of EBSD samples
- My analytical success often depends strongly on the quality of the EBSD sample preparation
 - EBSD does not work well if you do not get an EBSD pattern
- = Strong driving force for quality preparation

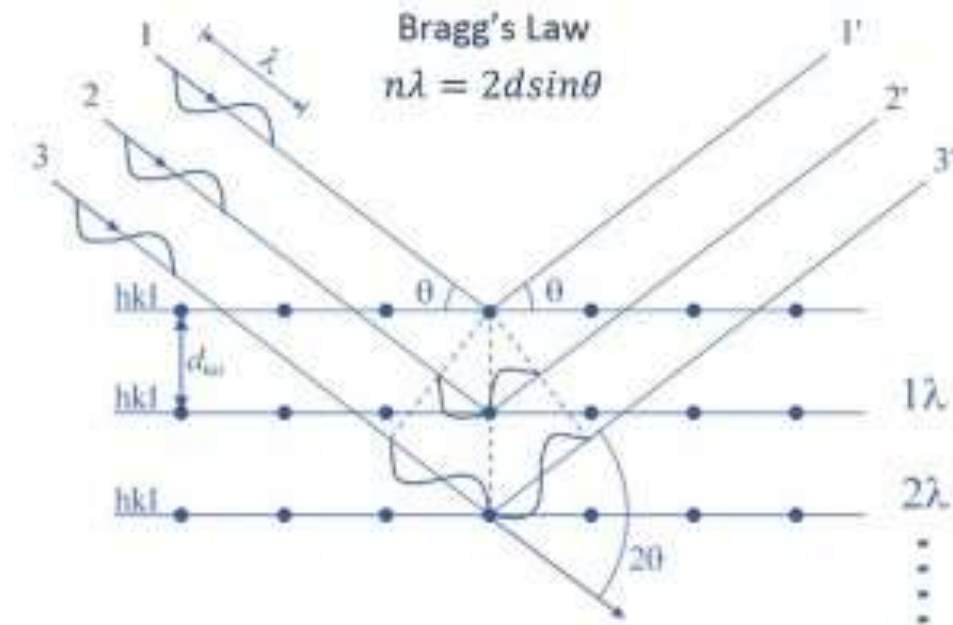
Sample Prep as Black Magic

- Often sample preparation can be seen like more of an art than a science
- Can make you feel like you are on the outside looking in if you don't know the magic spell
- Over time, you do develop a feel for what works

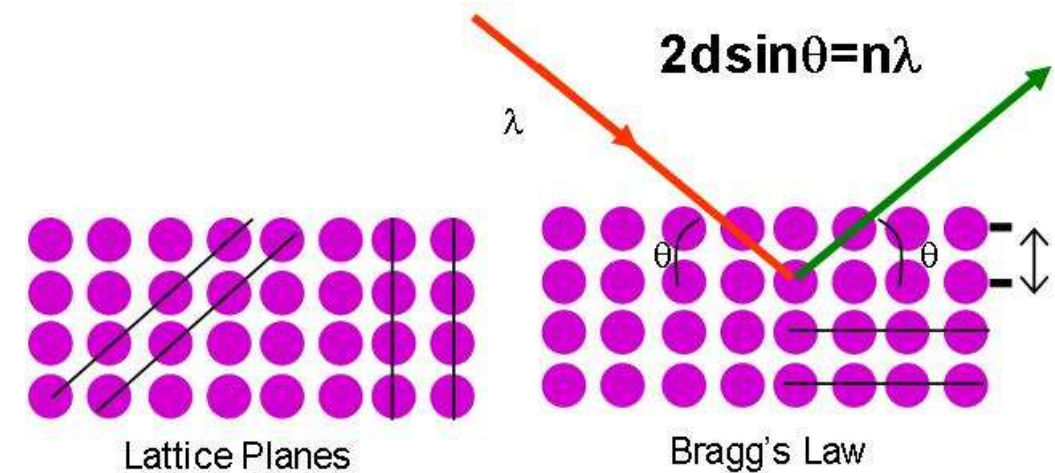


The D in EBSD is Key

- EBSD is a diffraction-based technique
 - Riding the electron wave
- The “better” the crystal lattice, the smaller the angular range where Bragg’s law is satisfied, and the more intense the diffraction for a given plane.
- Multiple planes diffract simultaneously with EBSD



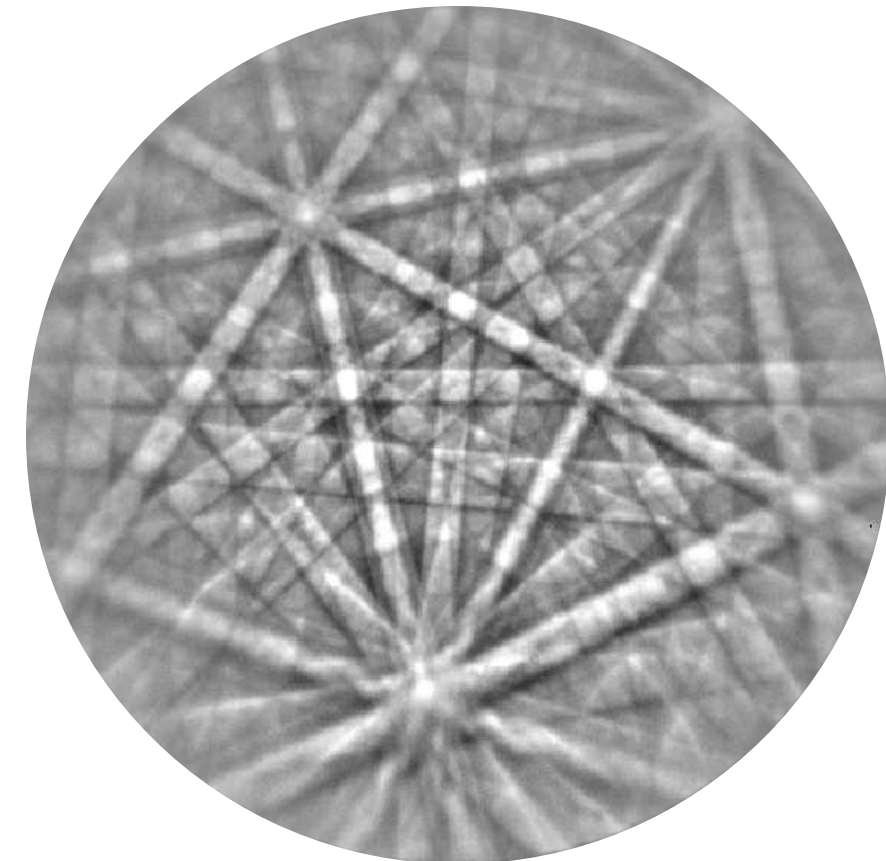
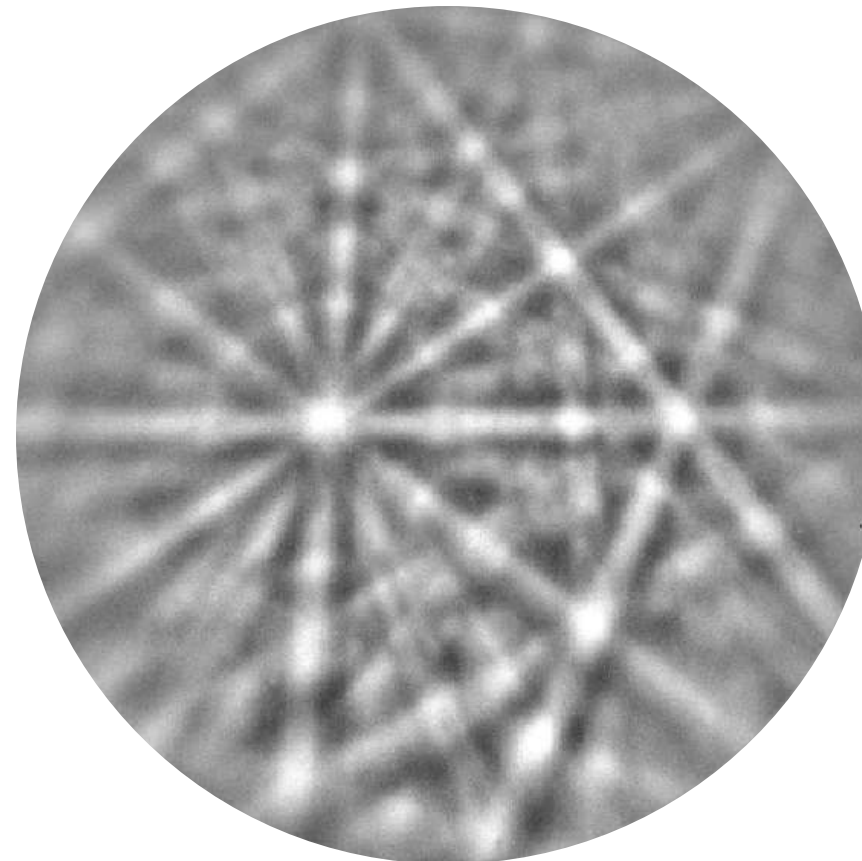
<https://publish.illinois.edu/x-raycrystallography/2014/12/18/introduction/>



[https://chem.libretexts.org/Core/Analytical_Chemistry/Analytical_Sciences_Digital_Library/JASDL/Courseware/Introduction_to_X-ray_Diffraction_\(XRD\)](https://chem.libretexts.org/Core/Analytical_Chemistry/Analytical_Sciences_Digital_Library/JASDL/Courseware/Introduction_to_X-ray_Diffraction_(XRD))

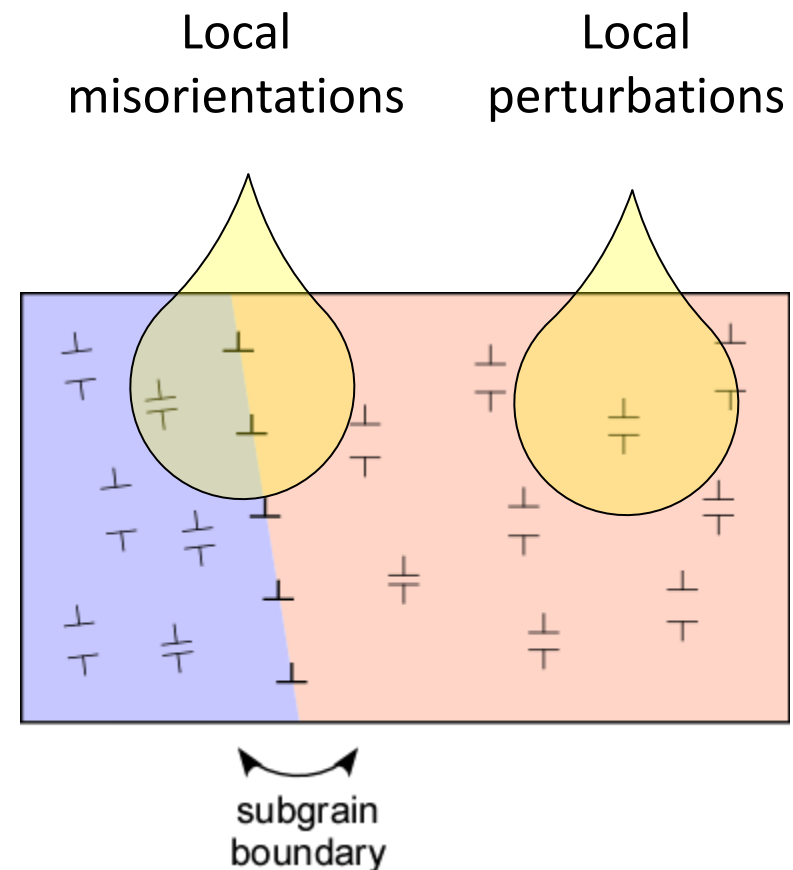
Better Preparation = Sharper Patterns (Ideally)

- EBSD patterns from ZrO_2 sample polished for SEM work (left) and for EBSD work (right).
- EBSD polish improves lattice quality at sample surface and sharpens diffraction bands.
- Want a representative lattice on surface after preparation



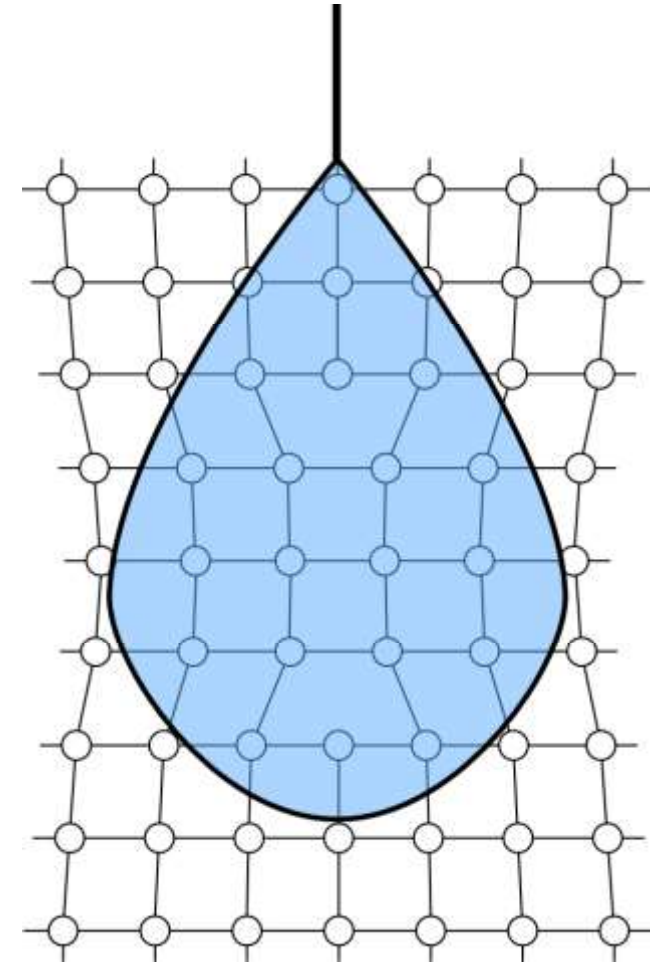
There is a Great Disturbance in the Lattice

- Dislocations present in a material can disrupt the periodicity of the local crystal lattice.
- Can cause local lattice curvature
- Can degrade EBSD pattern quality



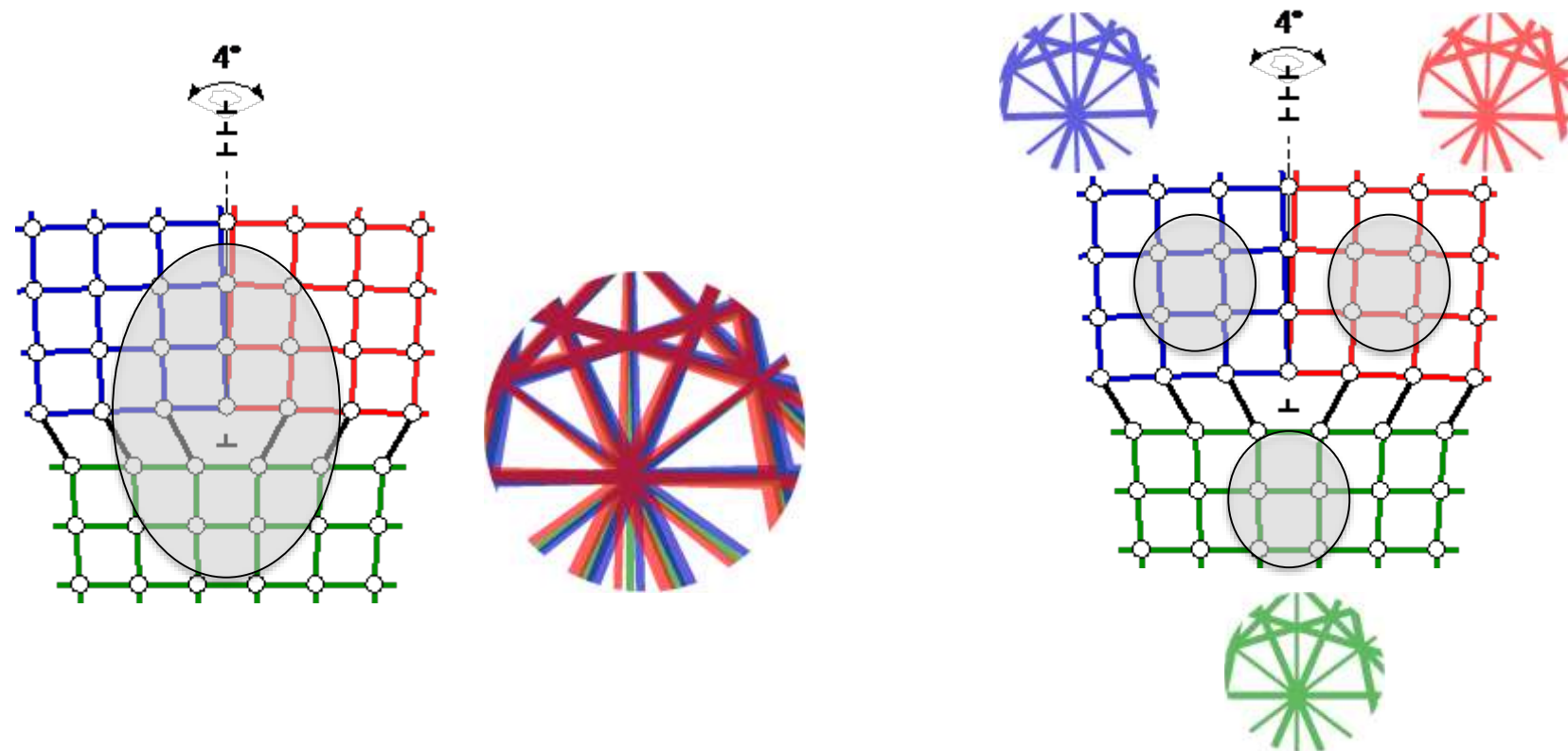
Statistically Stored Dislocations (SSDs)

- Dislocations are present, but with a net Burgers vector of zero
- Leads to degraded EBSD patterns
 - Can detect with EBSD Image Quality
 - IQ should be used carefully
- Effect depends on the interaction volume size within lattice distortion area
 - SEM Voltage
 - SEM Emitter



Geometrically Necessary Dislocations (GNDs)

- GNDs create small changes in crystallographic orientation or lattice curvature
- Interaction volume affects final EBSD pattern if sampling distorted lattice region



Why I Prepare EBSD Samples the Way I Do

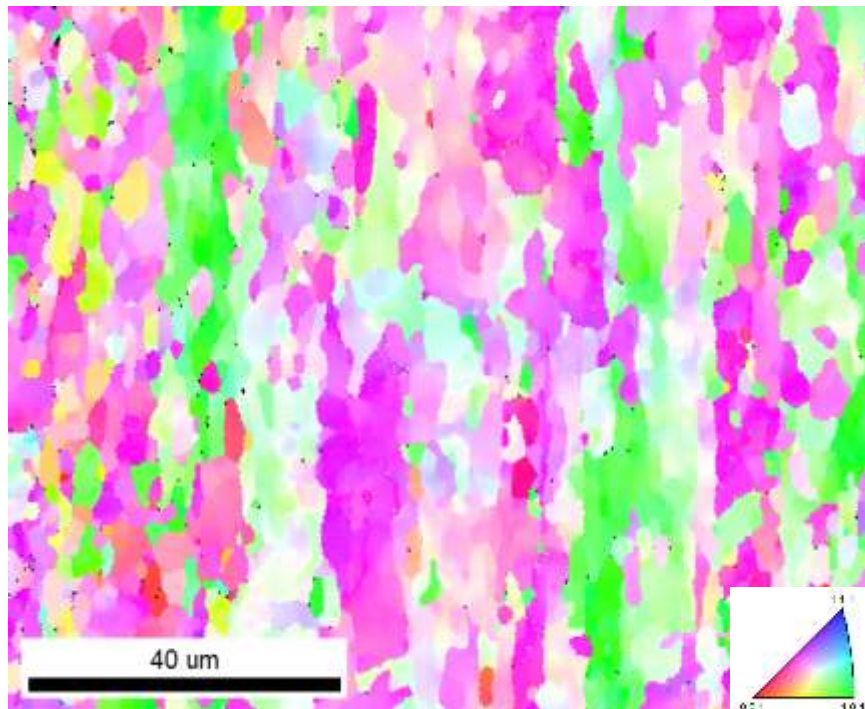
- Typically I am showing what EBSD can do for different samples, materials, or applications.
 - Want to make a good impression
- Sometimes comparing 2 or more samples
 - Want consistency for comparisons
- Look at a wide range of sample types
 - No typical sample
 - Often don't have many details about sample origin or history



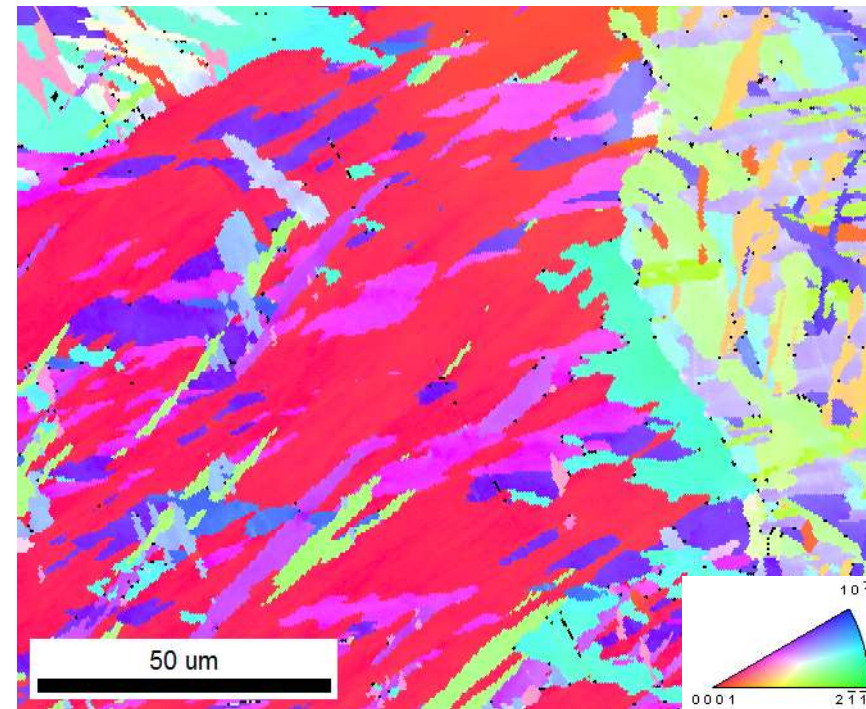
My Goal – 100% Indexing Success Rate

- \approx 100% ISR possible on range of materials and material states

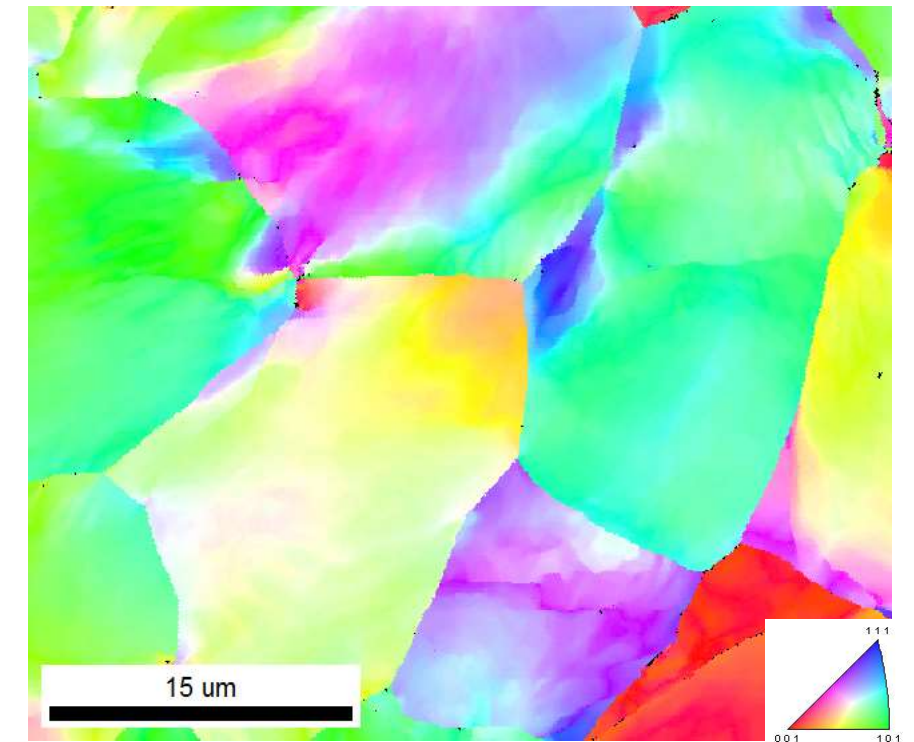
Rolled Aluminum
99.8% ISR



Ti6Al4V
99.5% ISR



Deformed Ferritic Steel
99.9% ISR

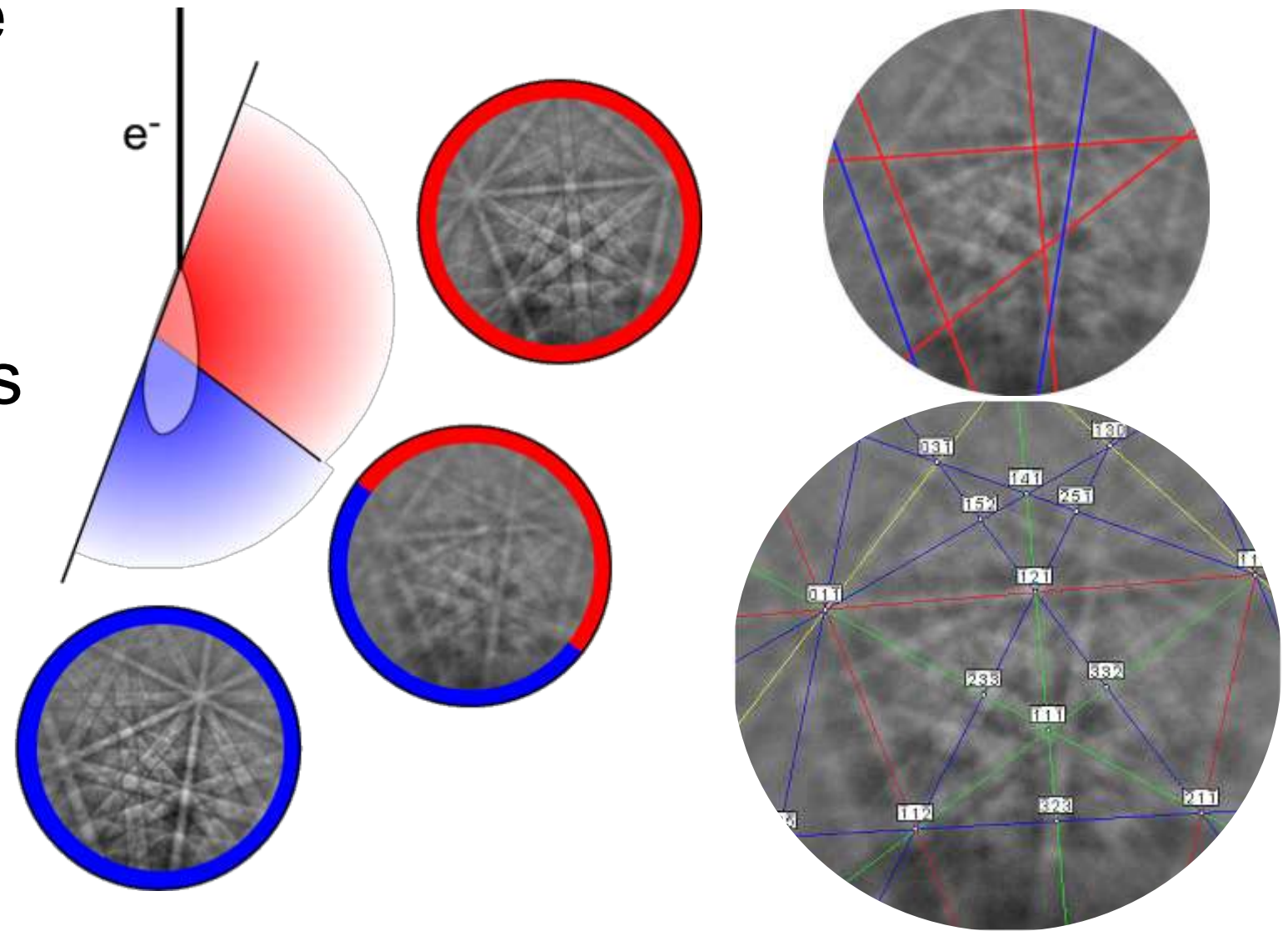


What Happens if I am < 100% ISR?

- While 100% ISR is nice, it's not always achievable
- It's beneficial to try and understand why collected points could not be indexed (or indexed correctly)
- This information may tell you more about your material and microstructure
- It helps to know how the EBSD pattern indexing works
- It might also tell you your sample needs further/better preparation

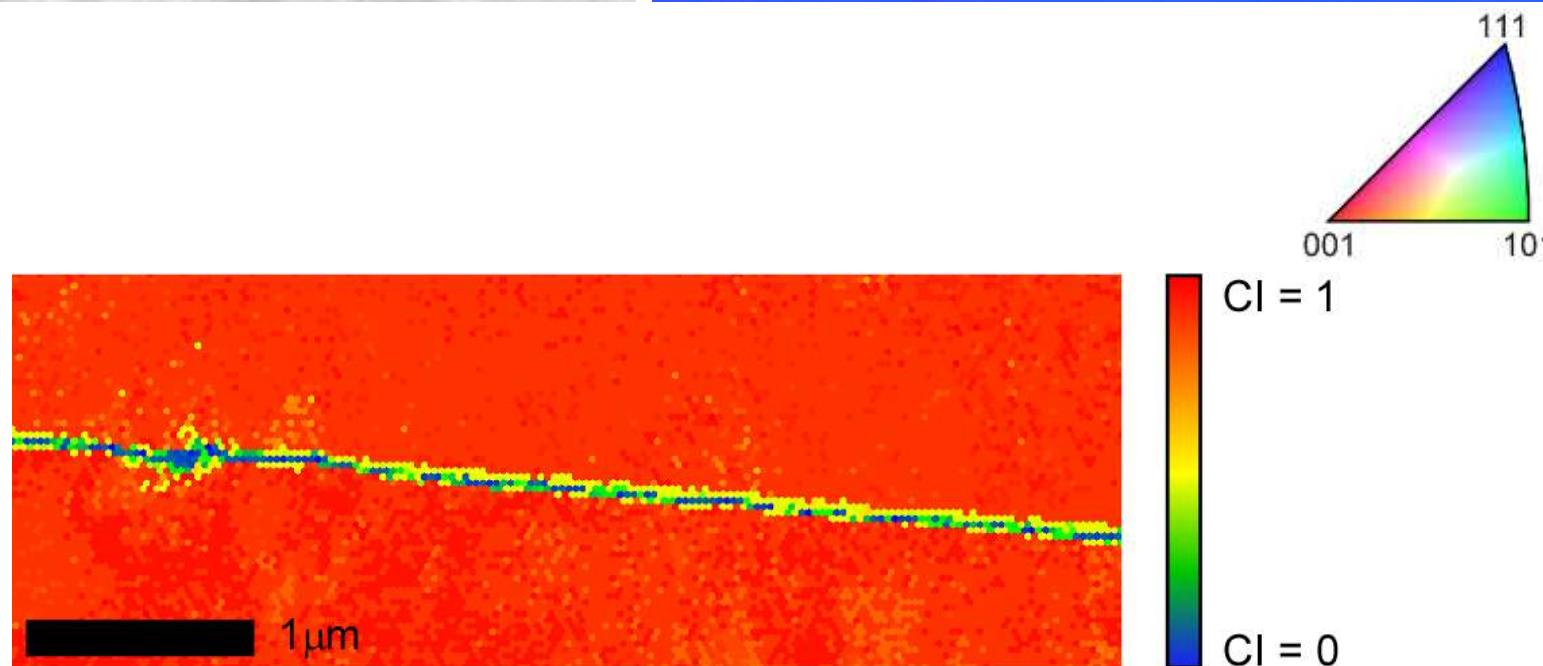
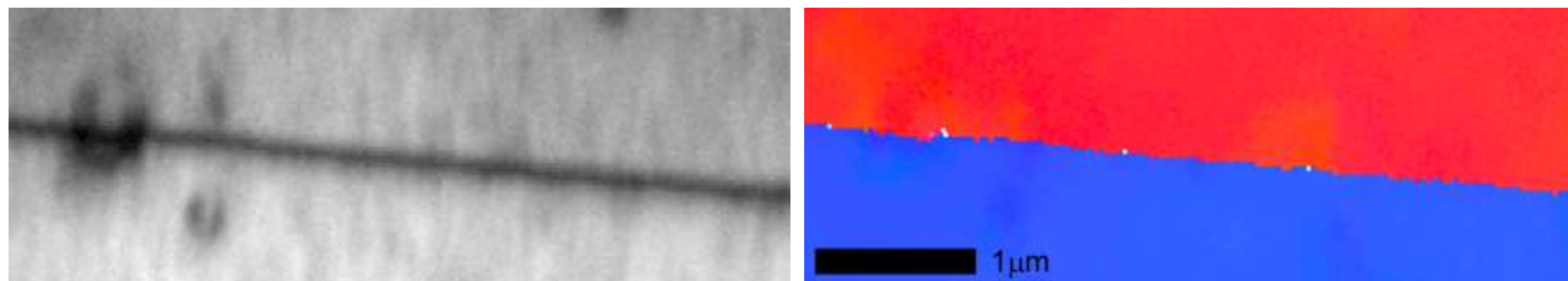
Indexing at Grain Boundaries

- Near grain boundaries, the interaction volume can sample multiple orientations causing overlapping EBSD patterns
- Sometimes these can be deconvoluted via indexing approach
- Grain boundary topography is also common



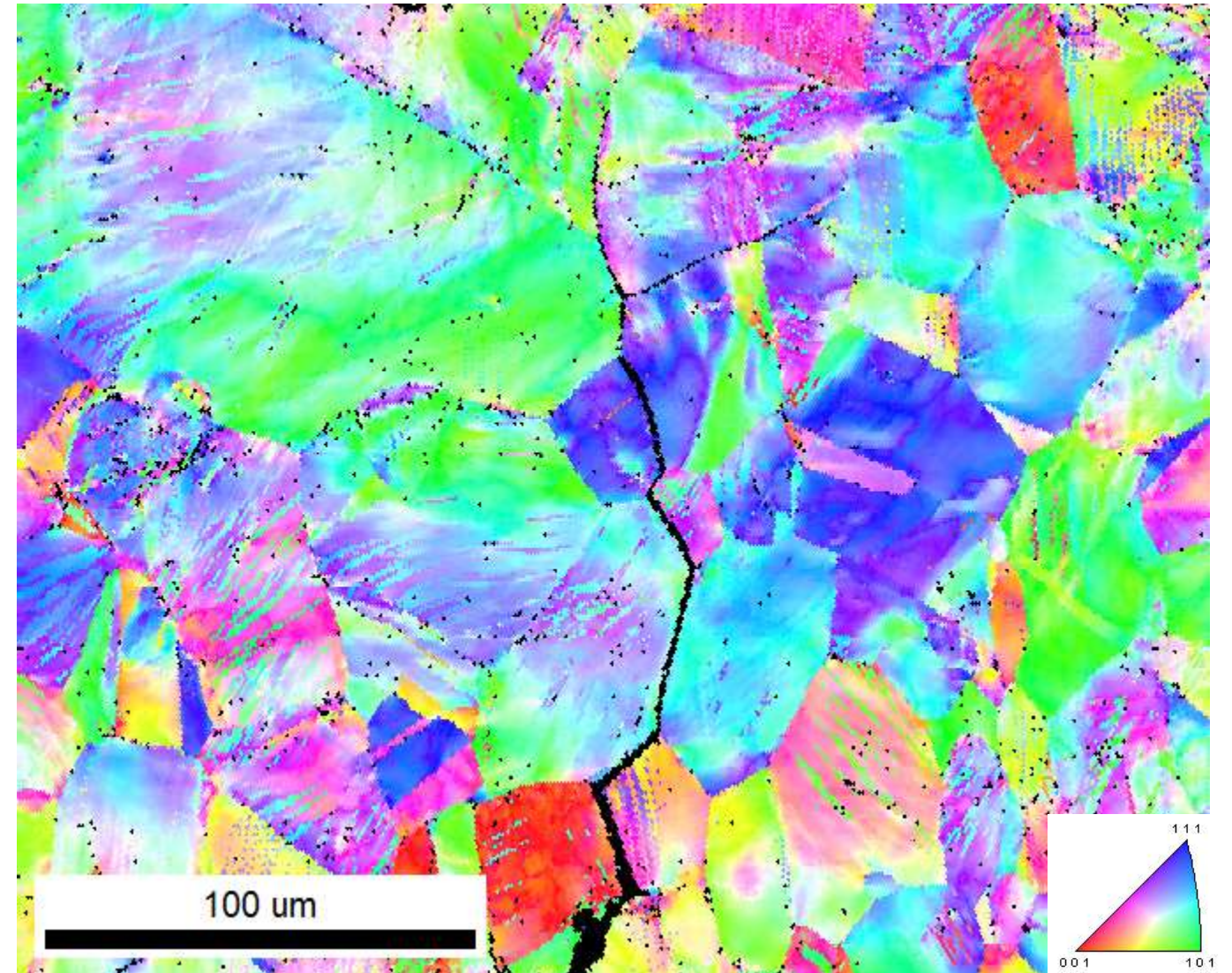
Indexing at Grain Boundaries

- In this case, we see a degradation of IQ and CI values at grain boundary, but a sharp change in orientation (no noise)



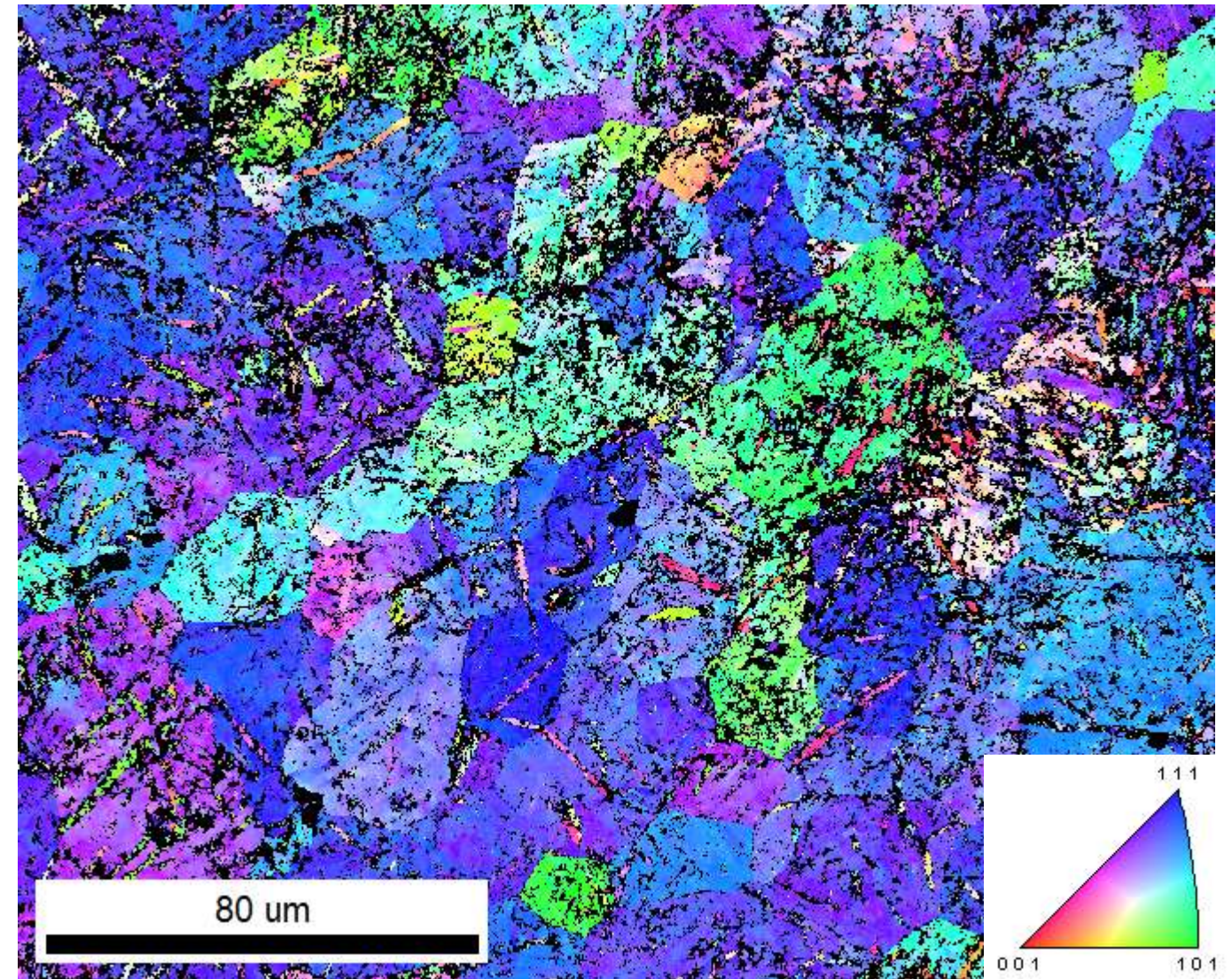
Crack Path

- Non-indexed points primary show the crack path through the microstructure of a pipeline steel
- Can be used to determine the grain boundary character of the crack propagation pathway

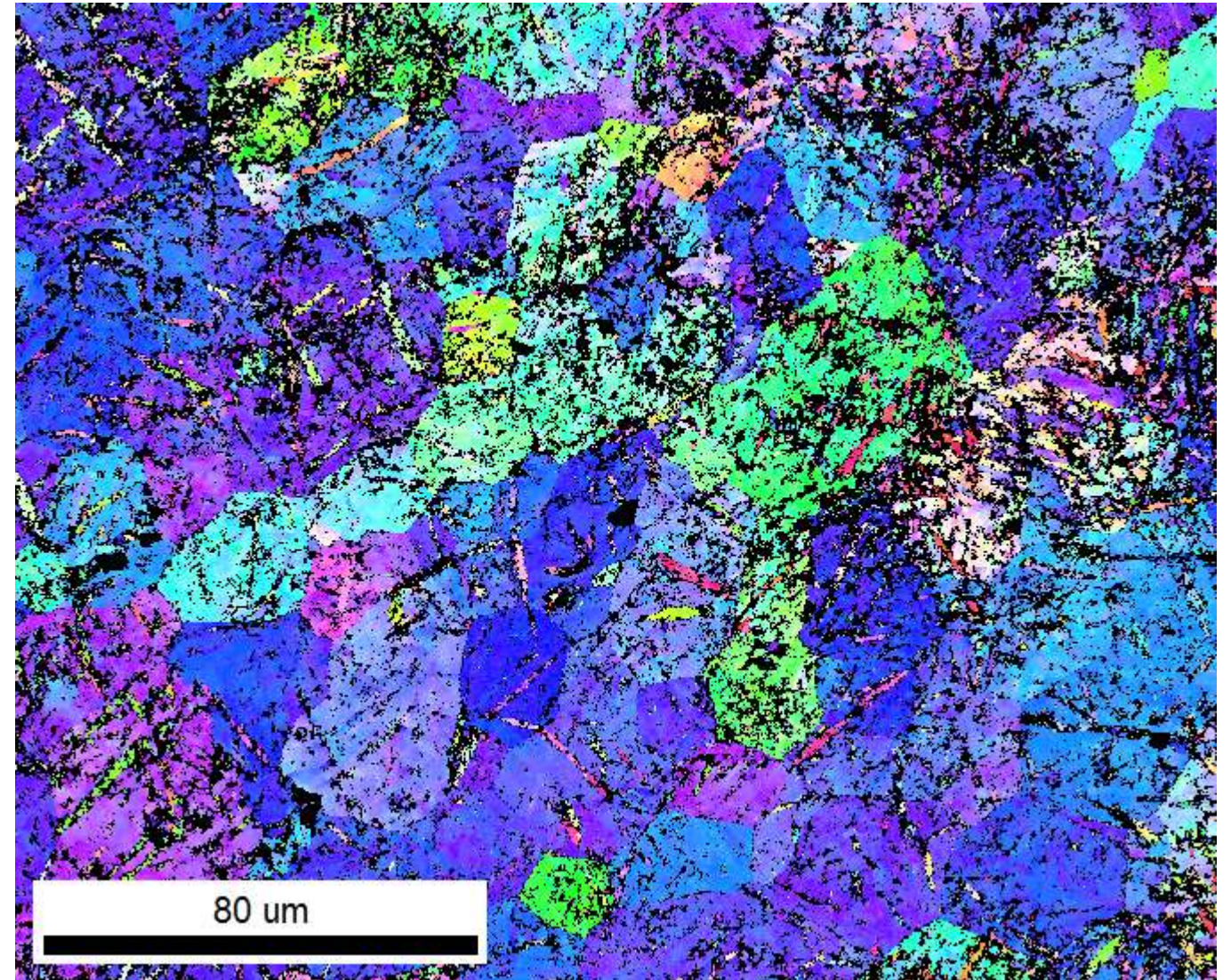
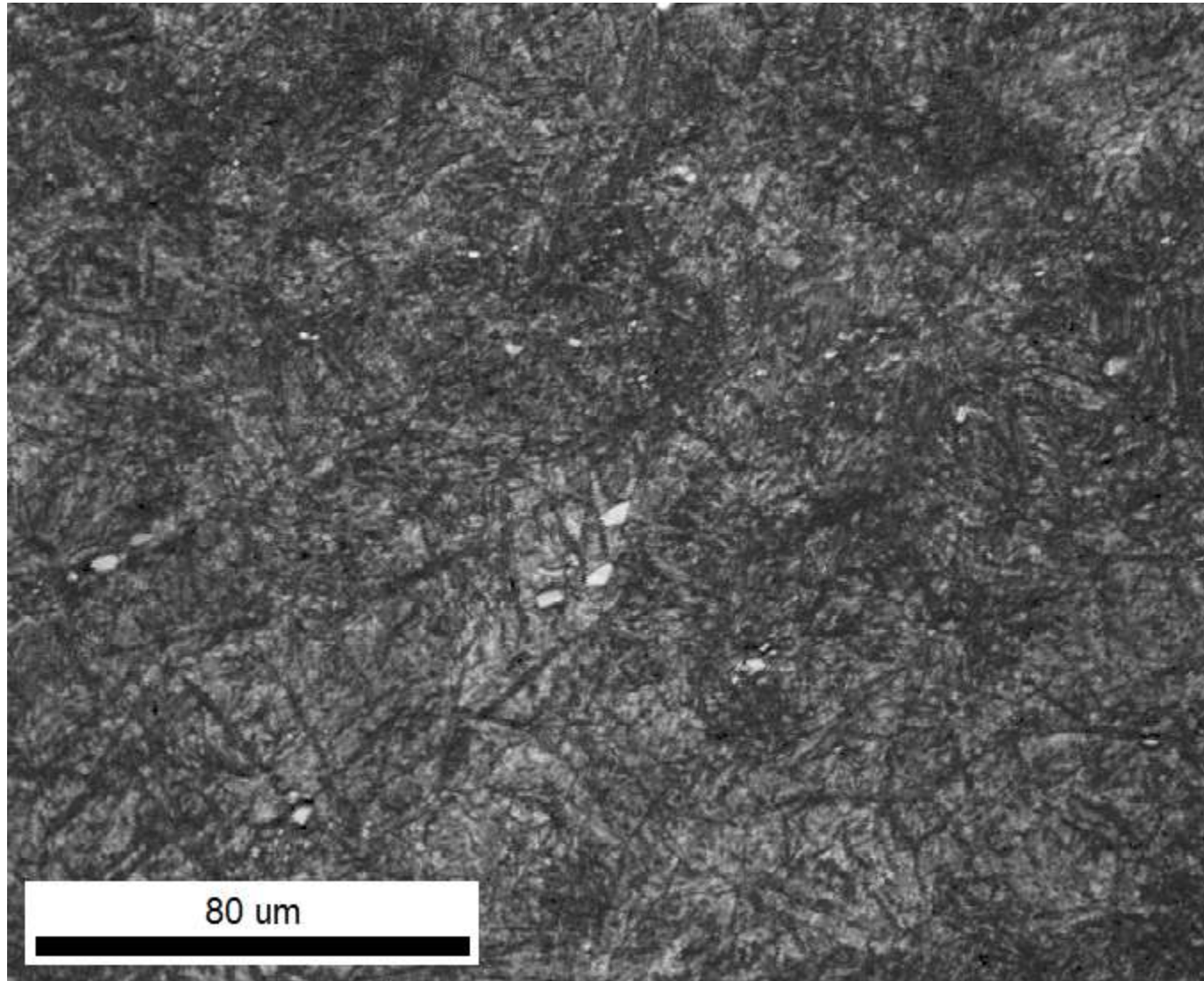


Plastic Strain and Lattice Deformation

- Lattice strain introduced into this Nitinol shape memory alloy degraded EBSD pattern quality
- The spatial shape distribution of the non-indexed points also suggest a 2nd phase present
- IQ, PRIAS, and EDS info can confirm this

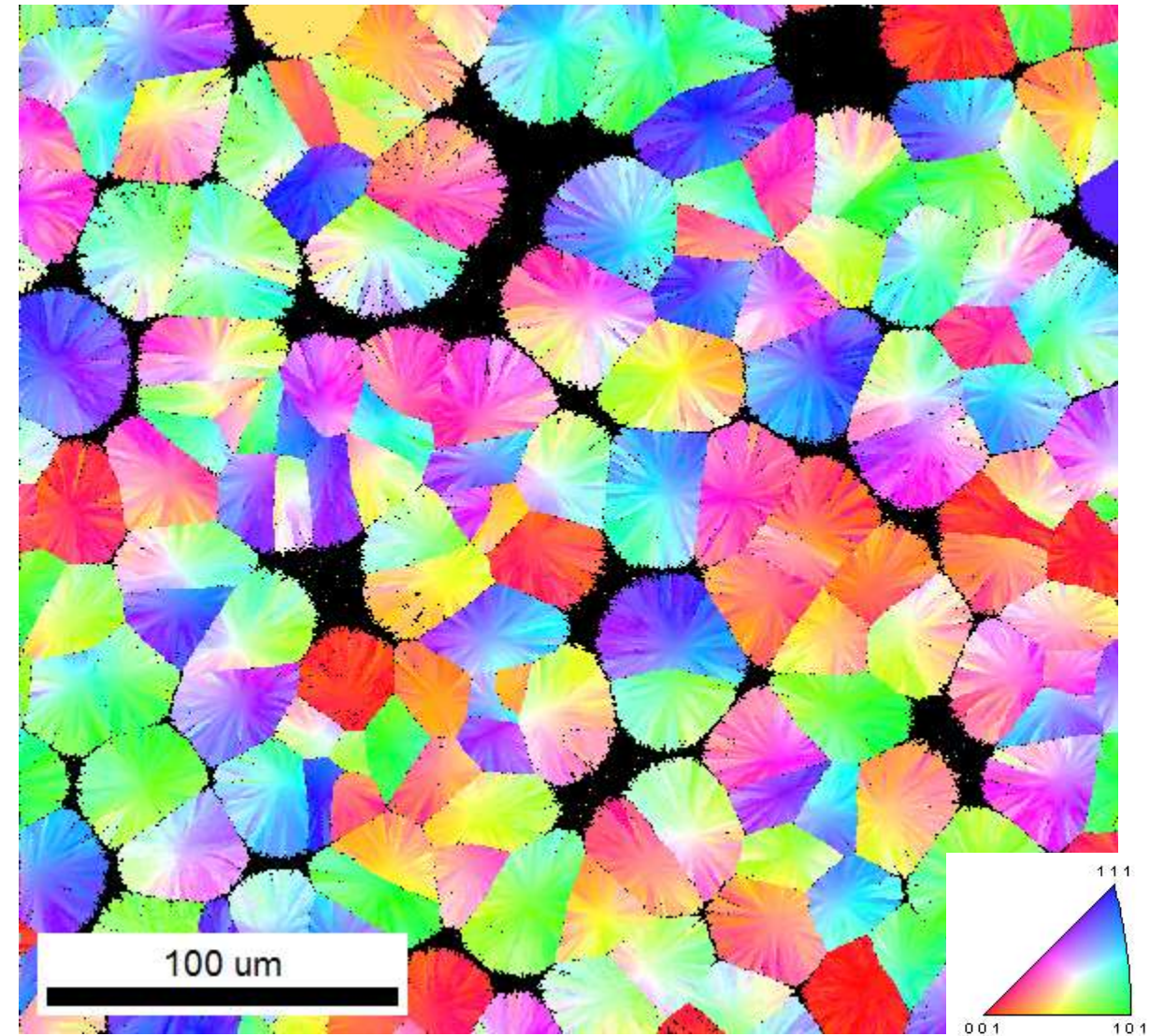


Other Phases



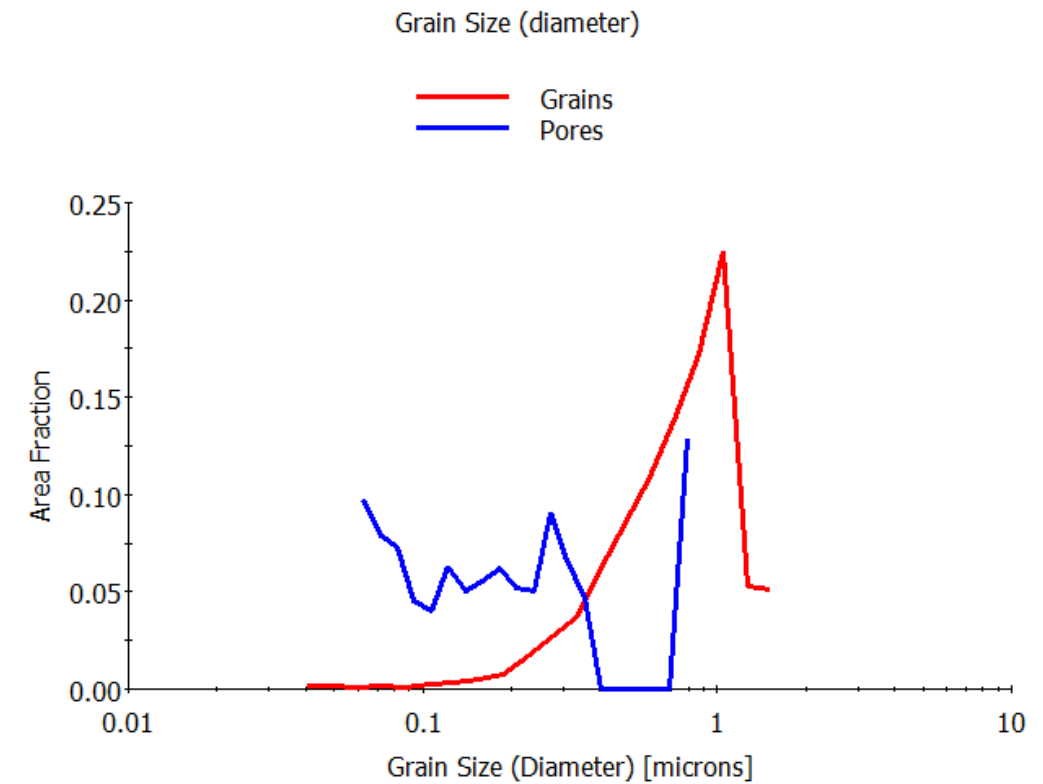
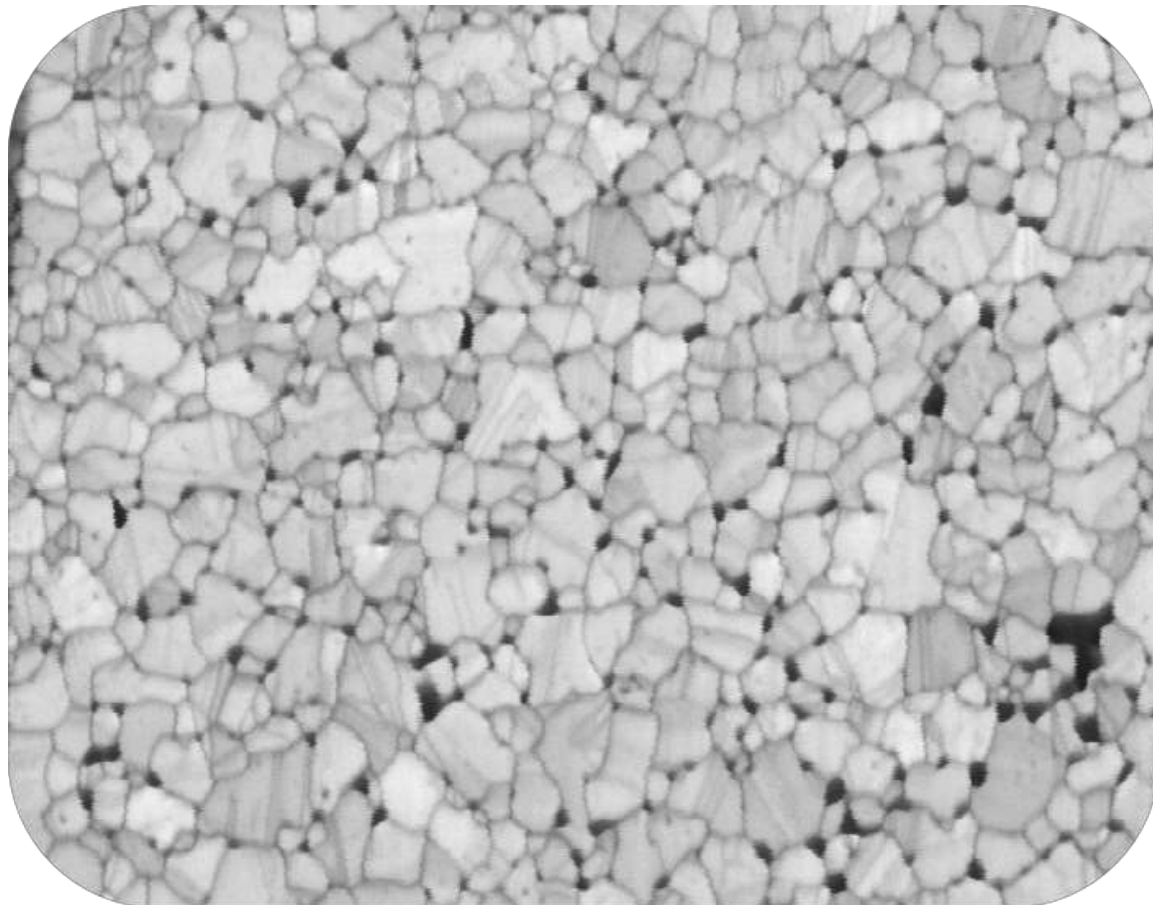
Amorphous Regions

- In this example, a thermoelectric material crystallizes within an amorphous film matrix
- While the lack of indexing, or of a visible diffraction pattern, does not prove its amorphous, it can be inferred from sample processing history



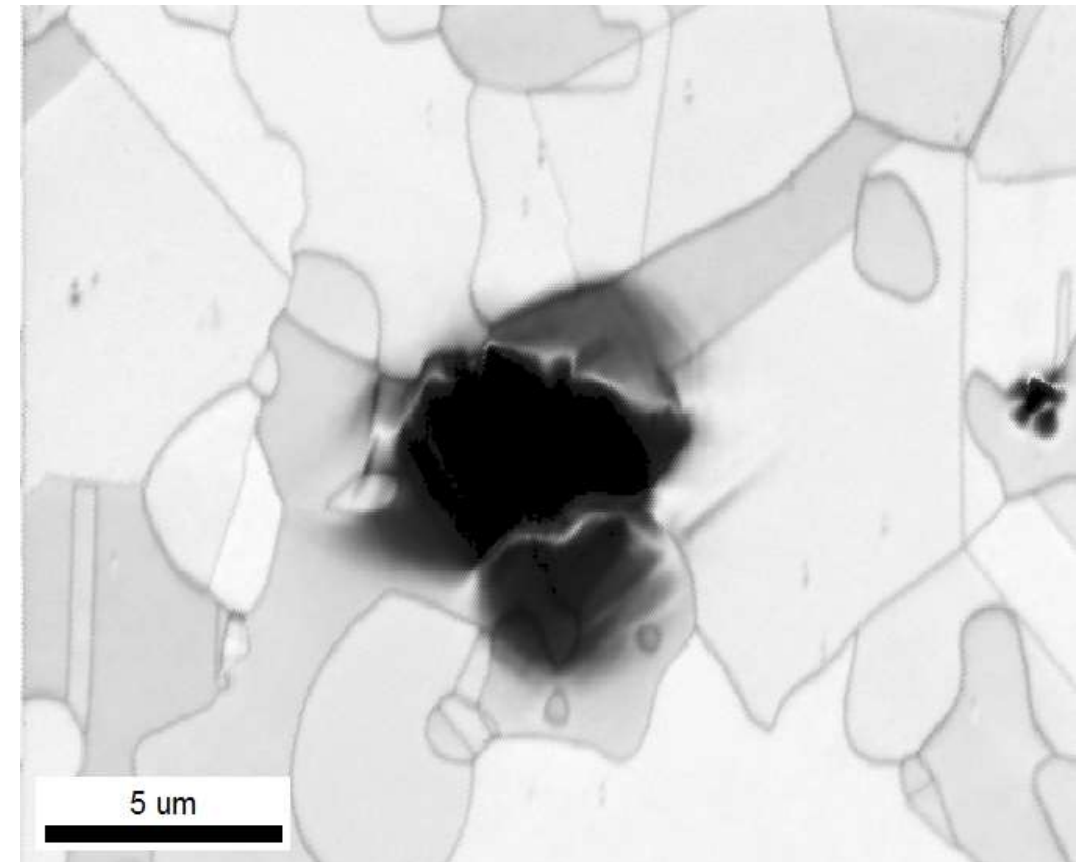
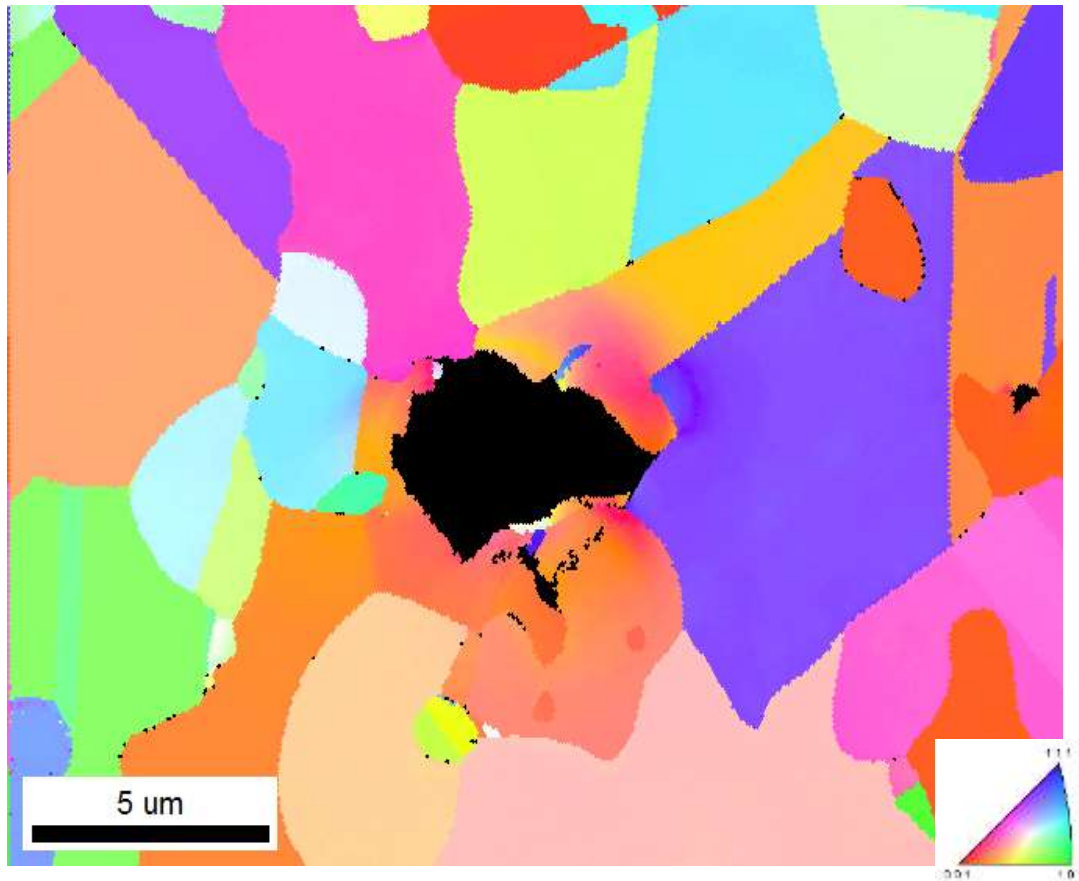
Porosity and Anti-Grains

- Non-indexed points can be grouped together spatially and analyzed (termed anti-grains) as in this CdTe solar cell thin film



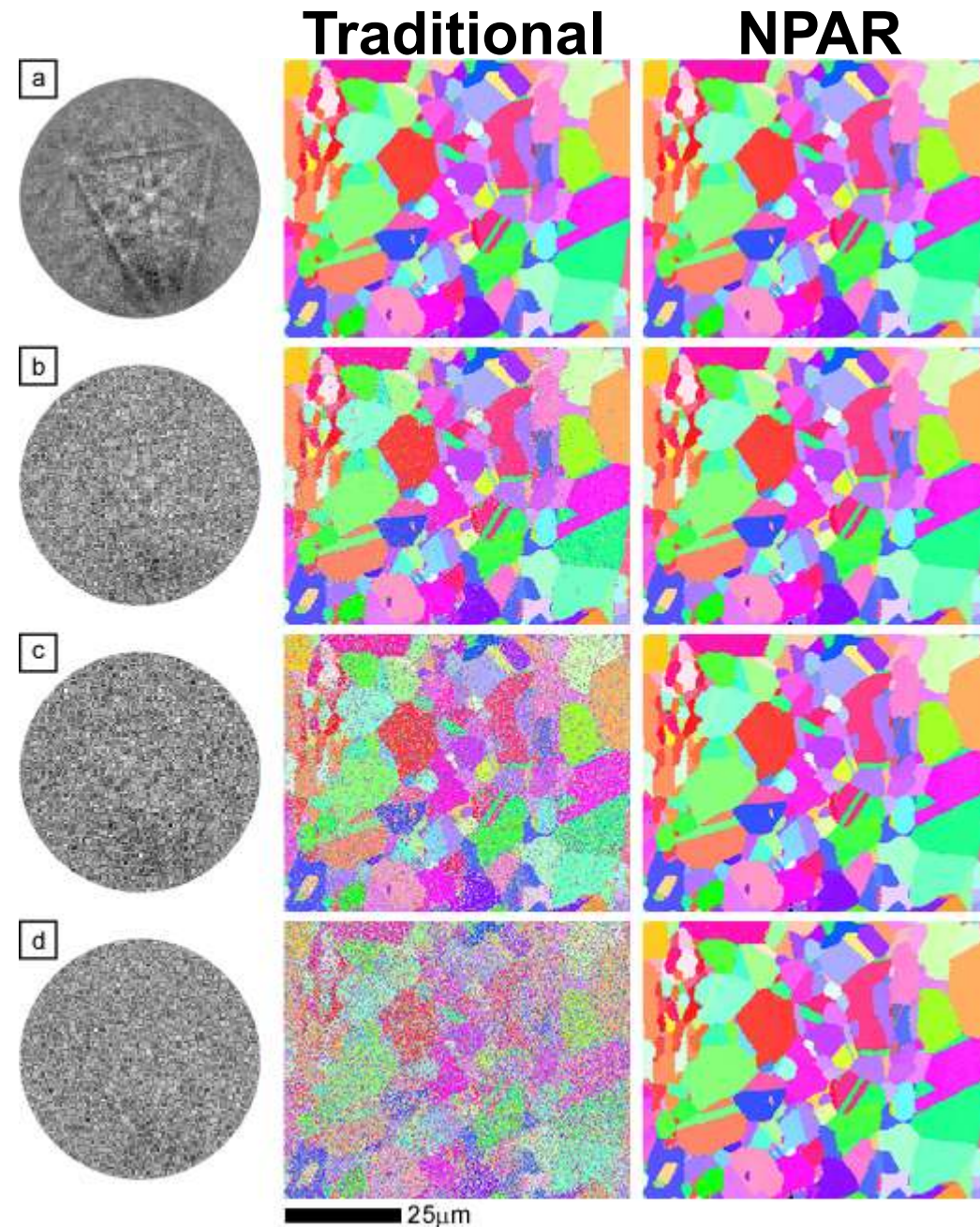
Surface Topography

- Topography introduced by nanoindentation causes regions that are blocked and causes bad indexing. Plastic strain visible in both orientation (left) and IQ (right) maps.

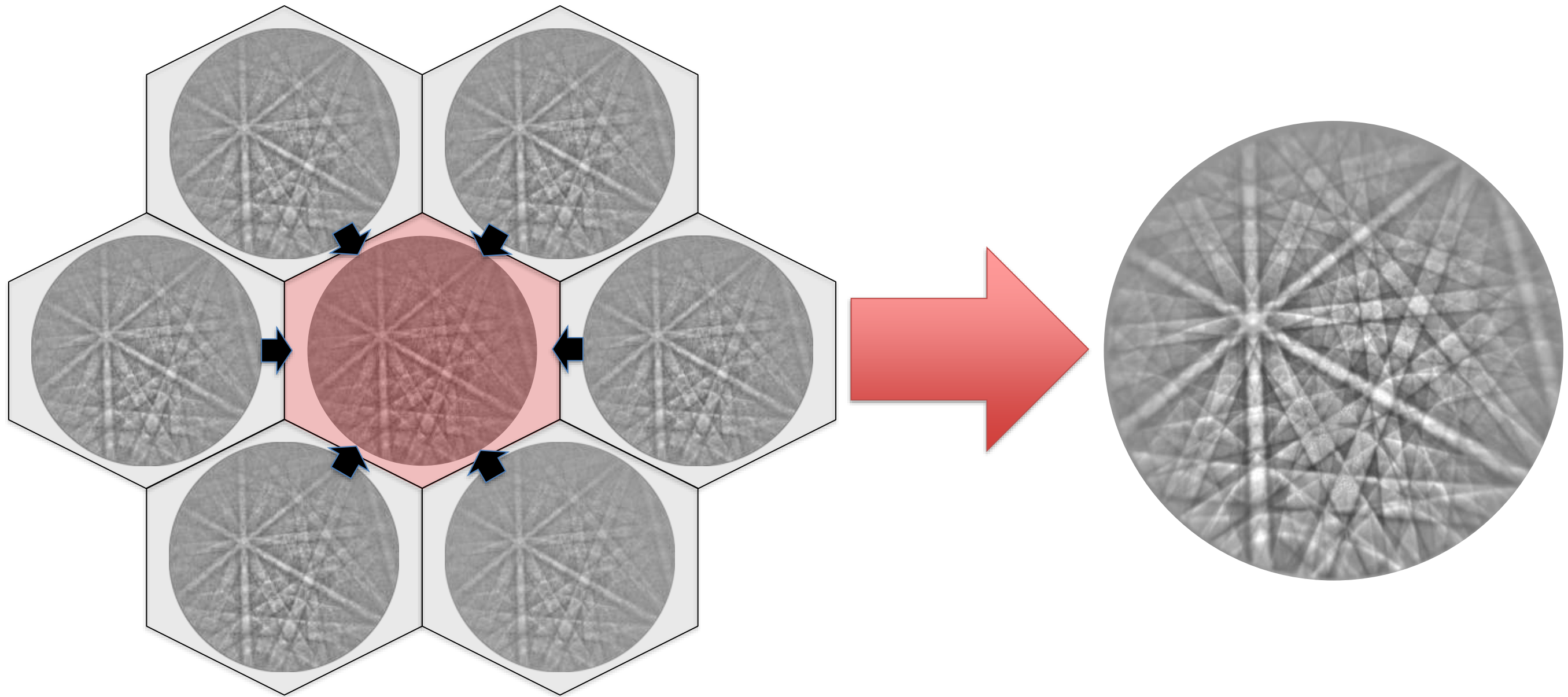


EBSD Camera Noise

- EBSD pattern signal to noise (SNR) levels can decrease due to faster acquisition speeds and/or lower beam currents
- At some SNR threshold (materials dependent), EBSD pattern indexing will fail
- NPAR can help



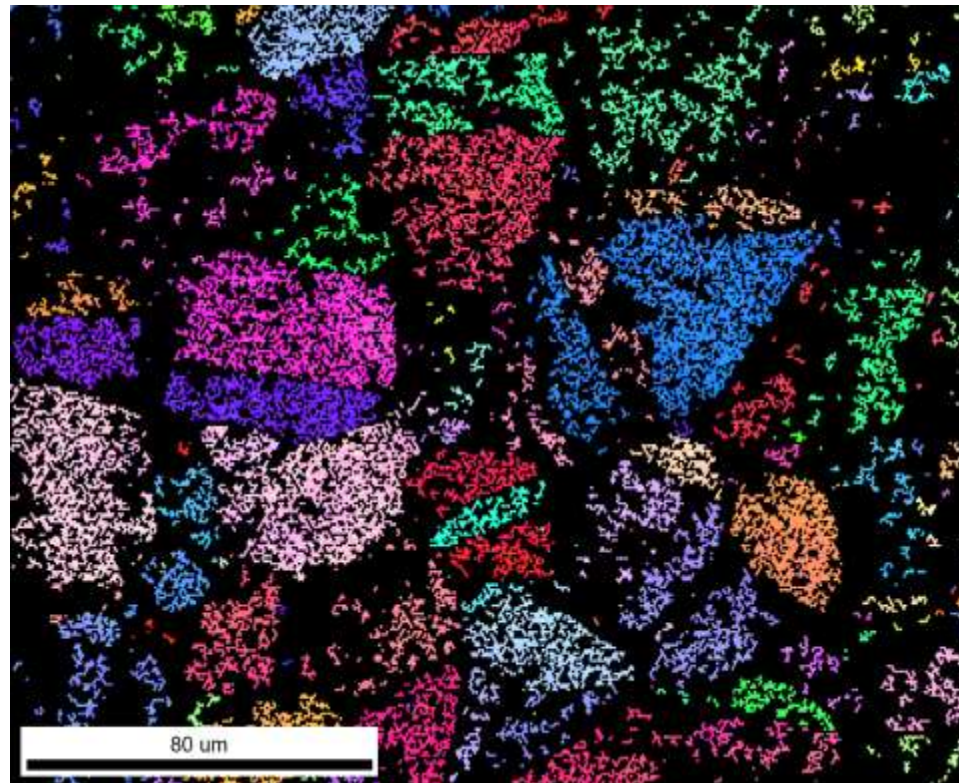
NPAR – Neighbor Pattern Averaging and Reindexing



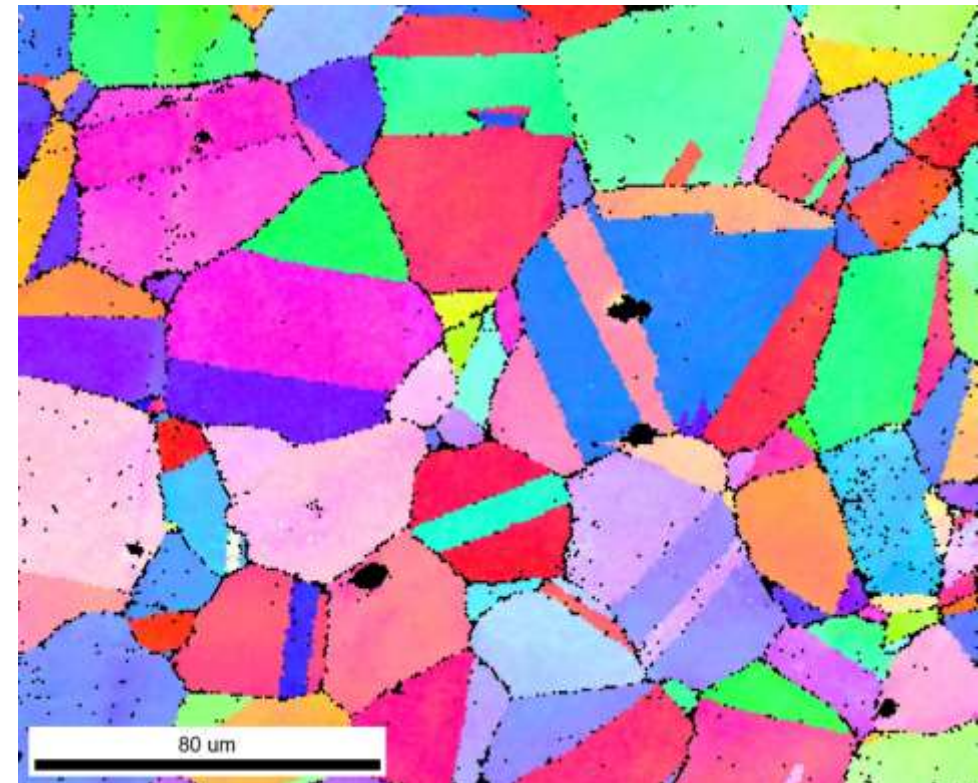
A new approach to improving S/N while maintaining acquisition speeds

NPAR for Reducing Camera Noise Effects

Traditional - 22% Indexing



NPAR - 96% Indexing

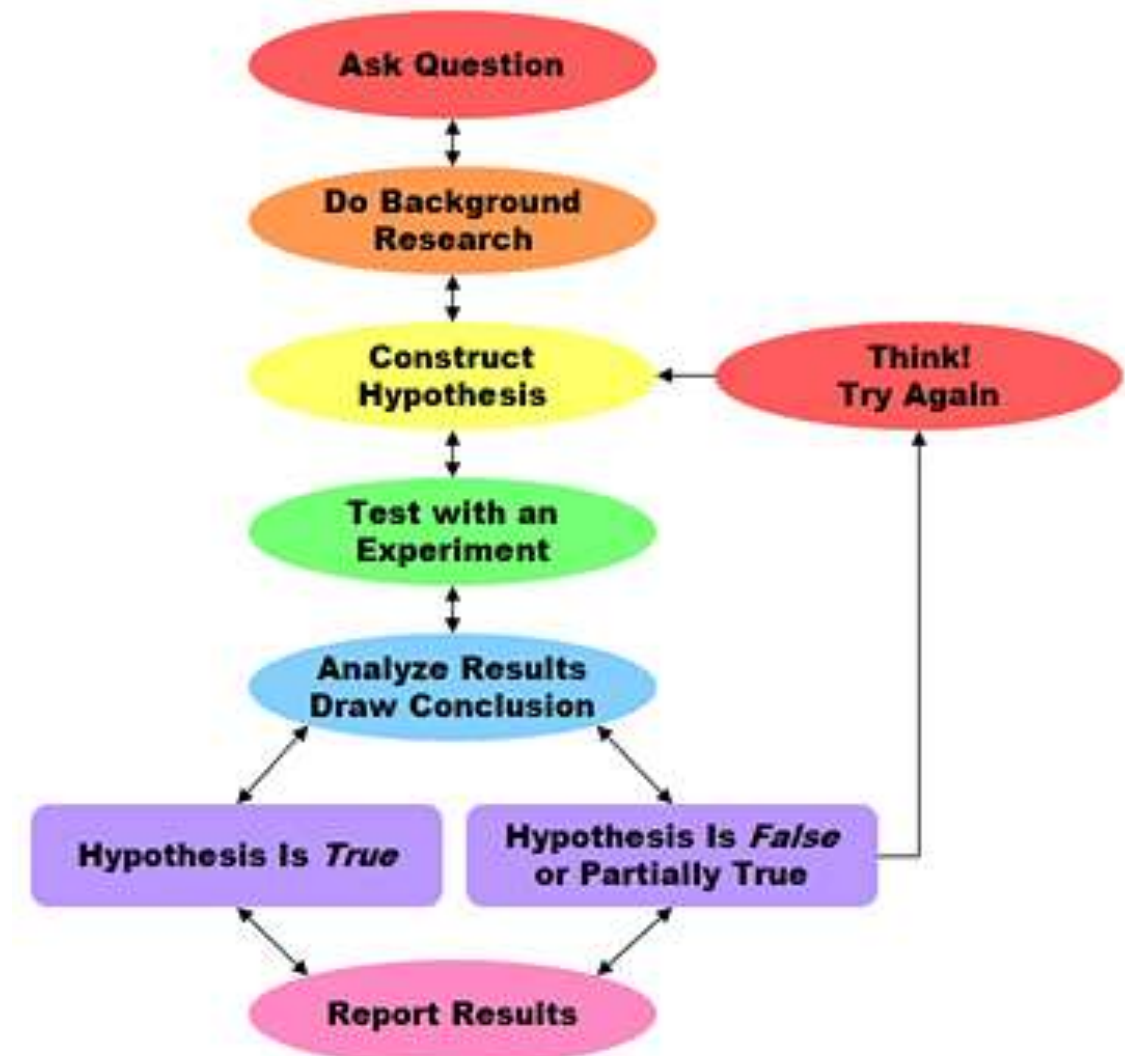


Is a 100% Indexing Goal for Everyone?

- Not necessarily
- Some threshold (90%, 95%, xxx) might be good enough
 - Does it tell you what you want/need to know?
 - Is any data lost or misrepresented?
- Will depend on the type of characterization or analysis is necessary
- Good practice though is to use consistent preparation routines when comparing samples
- Still good to try and understand why not reaching 100% ISR

Evaluating Sample Preparation Methods

- EBSD provides a great tool for evaluating the surface quality of a given preparation procedure
- Have used approach to qualify procedure for Inconel 600 EBSD standard material

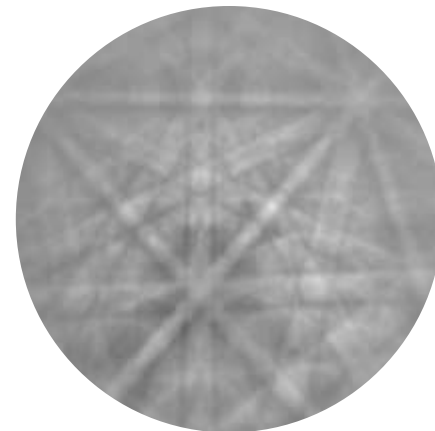


<http://weirdsciencekids.com/thescientificmethod.html>

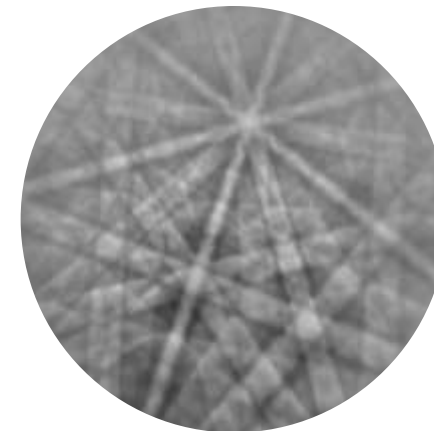
EBSD Patterns After Different Prep Steps



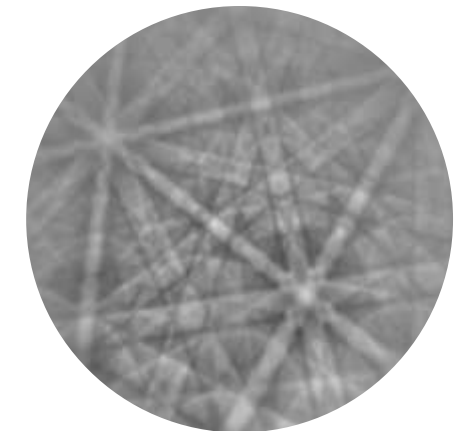
1200 Grit SiC



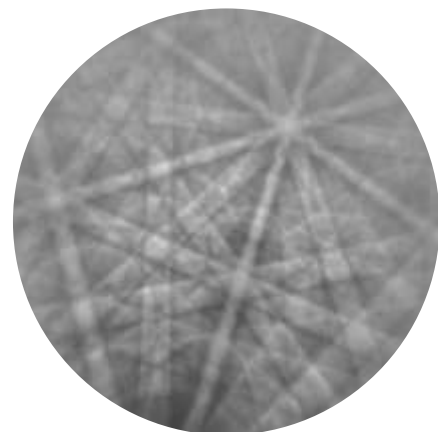
1µm Alumina



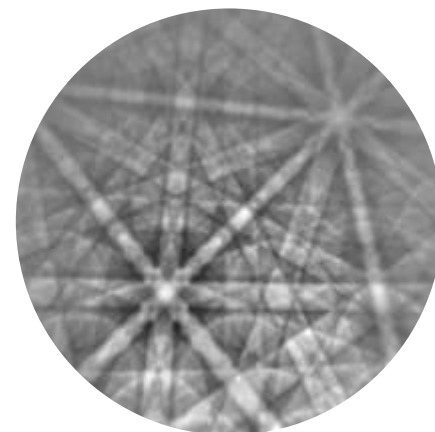
0.3µm Alumina



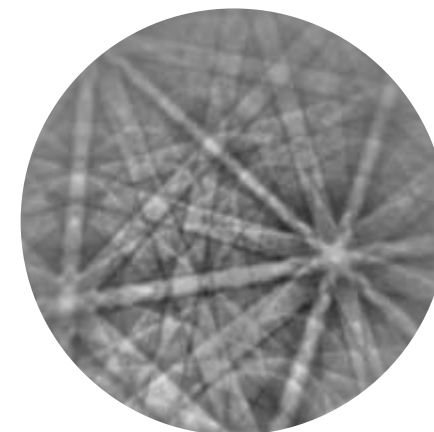
0.05µm CS 15 min



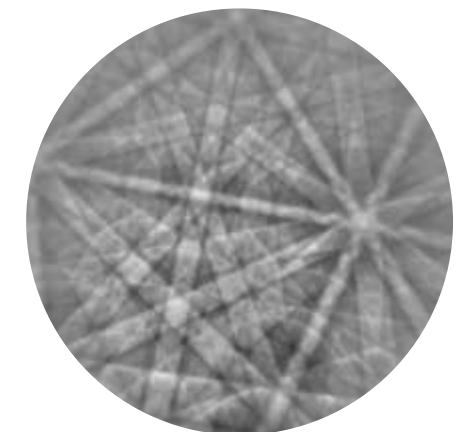
0.05µm CS 30 min



0.05µm CS 1 hr



0.05µm CS 2 hr

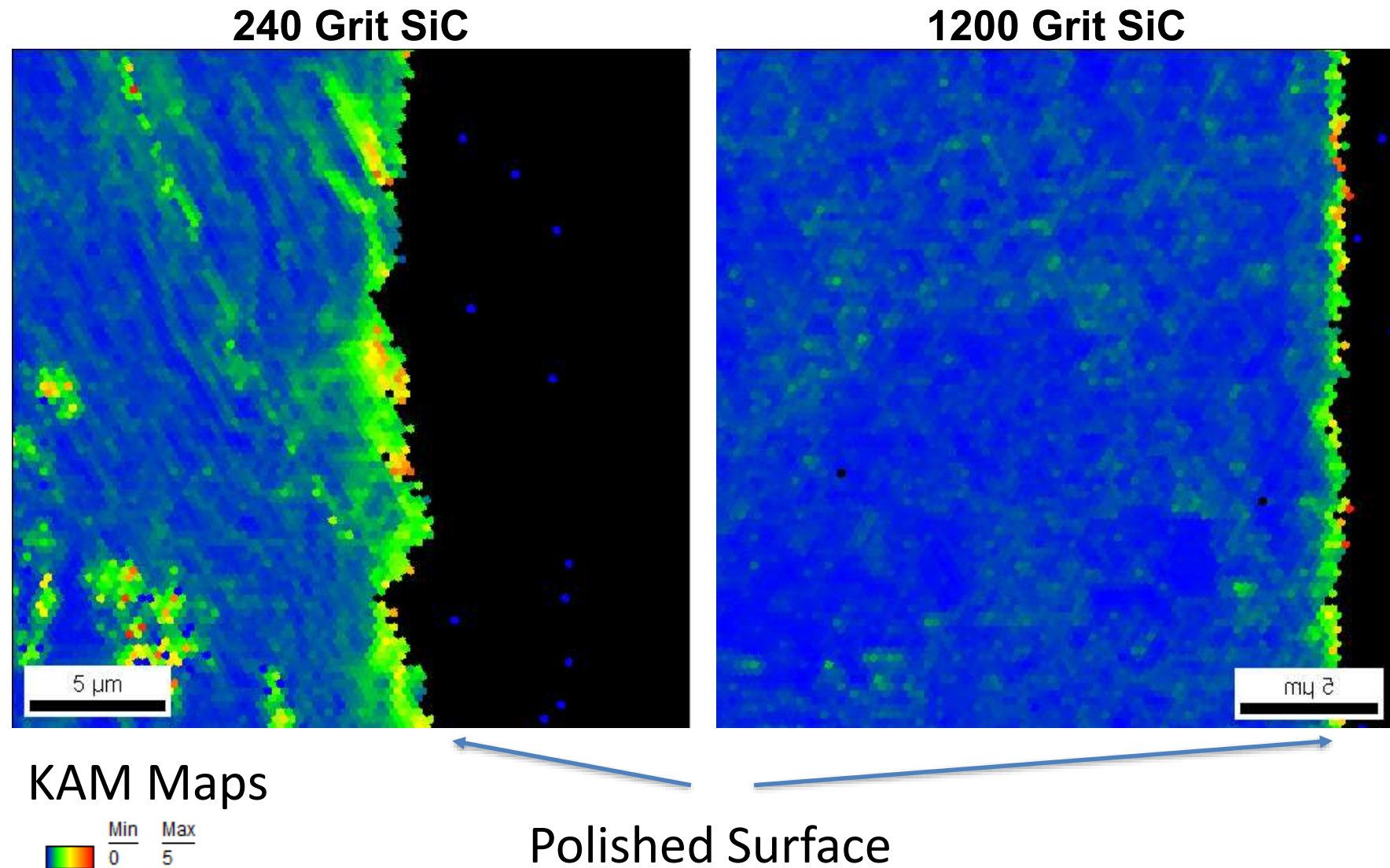


0.05µm CS 4 hr

Clearly there is an improvement from 1200 grit SiC to 1µm Alumina to 0.3µm and beyond. It is difficult to evaluate the difference other than visually however.

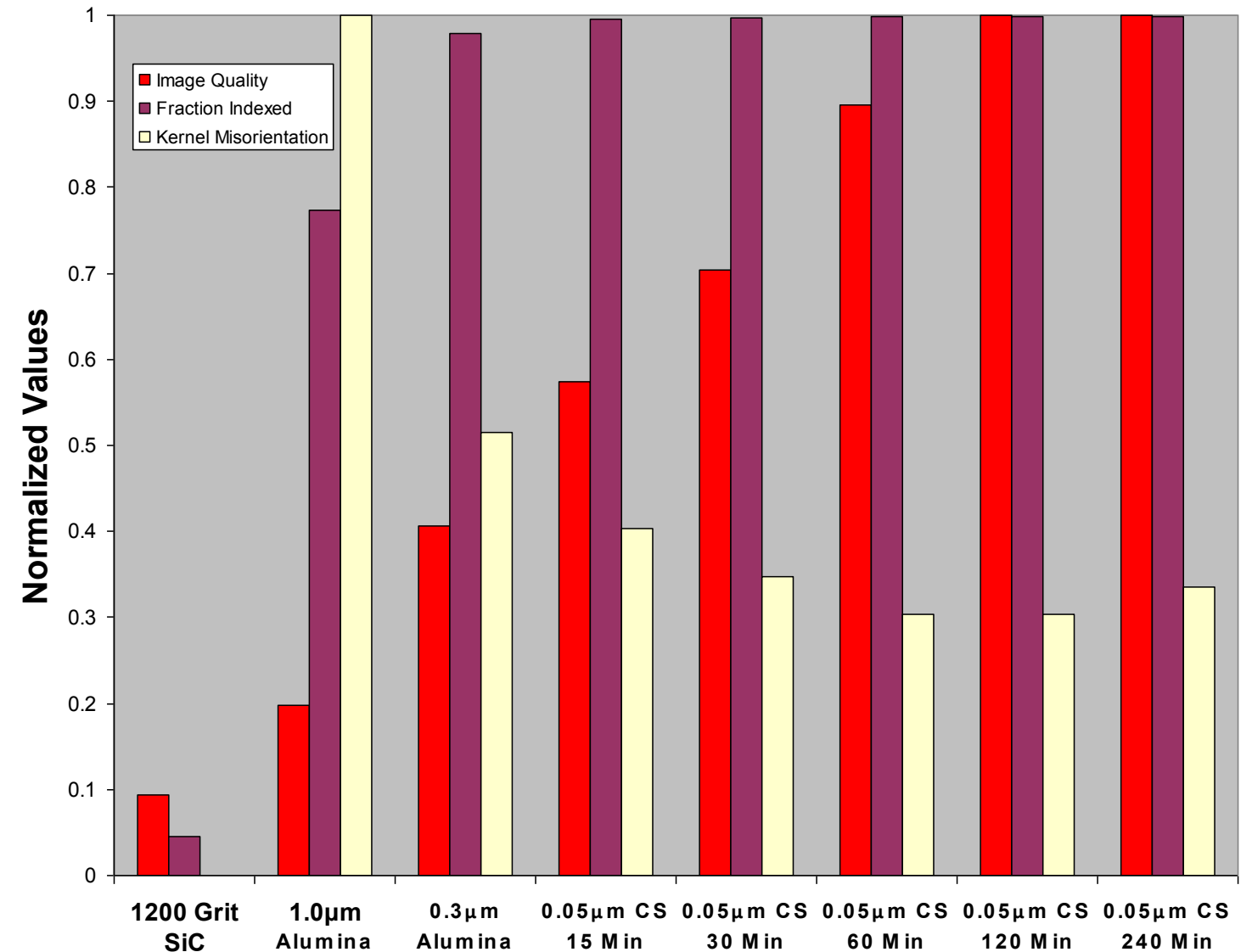
EBSD as a Tool to Evaluate Sample Preparation

- EBSD is an ideal tool for measuring plastic deformation on a small scale
- Can detect the deformation introduced/remaining after preparation (down to detection limits)



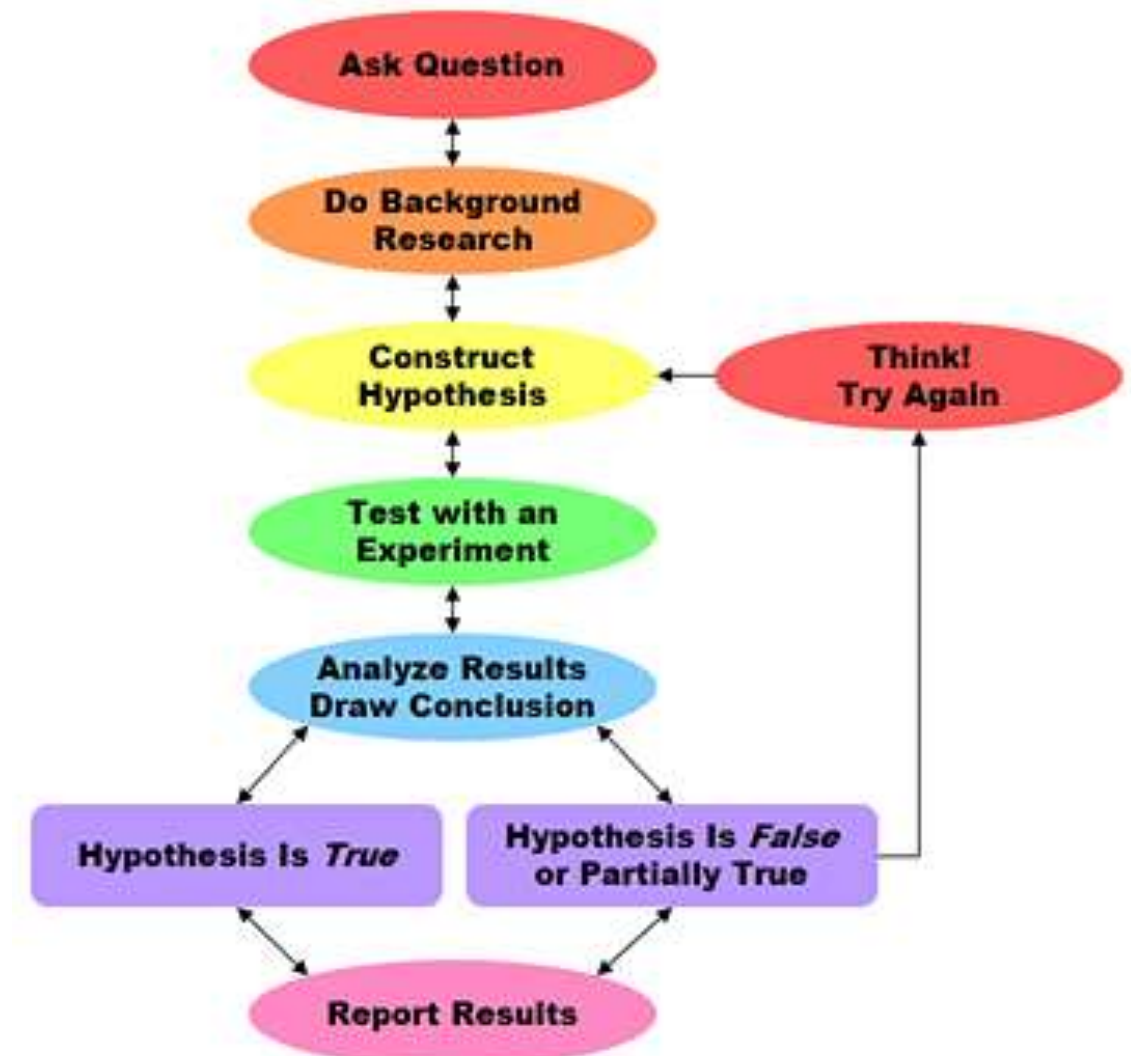
Evaluating Sample Preparation Methods

- This approach tells us 2 hours of colloidal silica is best
- I rarely take this approach as I look at a wide range of materials and each sample/material can behave differently
- Will offer more opinions that I haven't verified as fact



Evaluating Sample Preparation Methods

- I will explain what I do, and why I do it
- Much of the reasons why are based on opinion and theory, but I have not systematically tested
- New tools and approaches are available, but I haven't tried all
- Disclosure: I have not monetary stake in any sample preparation company. These are the products I use.



<http://weirdsciencekids.com/thescientificmethod.html>

Mounting Sample

- I generally use a TechPress2 from Allied High Tech
- Uses heat and pressure, so sample must tolerate this
- I like this approach because its fast (< 10 minutes) and reproducible
- The more specific details I can share, the easier to reproduce for others



Mounting Compound

- I use the ProbeMet compound from Buehler
- I liked it when I first used it in 1998
- It is a Cu and SiO₂ filled epoxy thermoset, with good edge retention
 - Feels lighter than other compounds with more Cu
- It is not perfectly conductive, but it does help
- Generally I use 1" mounts, but have done 1.25" and 1.5"
- I use instructions on the package
 - 150° C, 290 bar pressure, 3 minute pre-heat, 1 minute-heat, 3 minute cool with water

Mounted Sample

- 1" Mounts allow for easier tilting to EBSD conditions while examining more of the sample area
- I try and measure the amount of compound to use to get a consistent sample height
 - Will depend on height/volume of sample



Epoxy

- When a sample cannot tolerate thermoset resin, I use an epoxy mix – Generally I use Allied High Tech EpoxySet
- Hard, clear epoxy with low curing temperature (54°C) and no shrinkage
- ≈ 8 hour cure time – can be reduced via heating
- Non-conductive, but I have mixed in Buehler Conductive Filler to improve performance, but makes mount opaque

Epoxy Samples

- Need to use spray to make removing from mounting cups easier
- Sometimes the back side of the mount is rough, and can be tricky to cut to get front and back sides parallel
 - Can influence precision of tilt values and beam position



Grinding and Polishing

- I use an Allied High Tech MetPrep 3 with Power Head
- I used adhesive backed SiC 8" disks
- Can set individual or central force
 - Was strong driving force in initial purchase
 - Often preparing single sample
- Can adjust time, force, and rotation direction



Grinding with Silicon Carbide (SiC) Papers

- I use 8" adhesive SiC papers
 - 240 grit
 - 320 grit
 - 400 grit
 - 600 grit
 - 800 grit
 - 1200 grit
- My final SiC abrasive size is $\approx 5\mu\text{m}$



SiC Papers are Consumables

- For each grit, I use 2 SiC papers for 30 seconds each
 - Insures fresh and effective abrasive
 - Can feel it's used after 30 seconds with finger
- I run with 10lbf and 150 RPM on the platen
 - Can calculate pressure if necessary
- I use complementary rotation with the platen and the head
 - Helps keep front and back sides of sample parallel
 - Better for ComboScan larger area maps

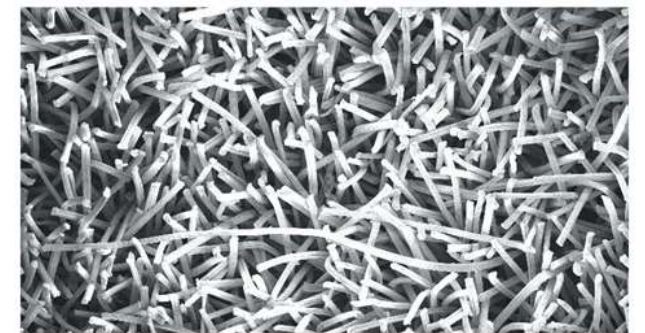
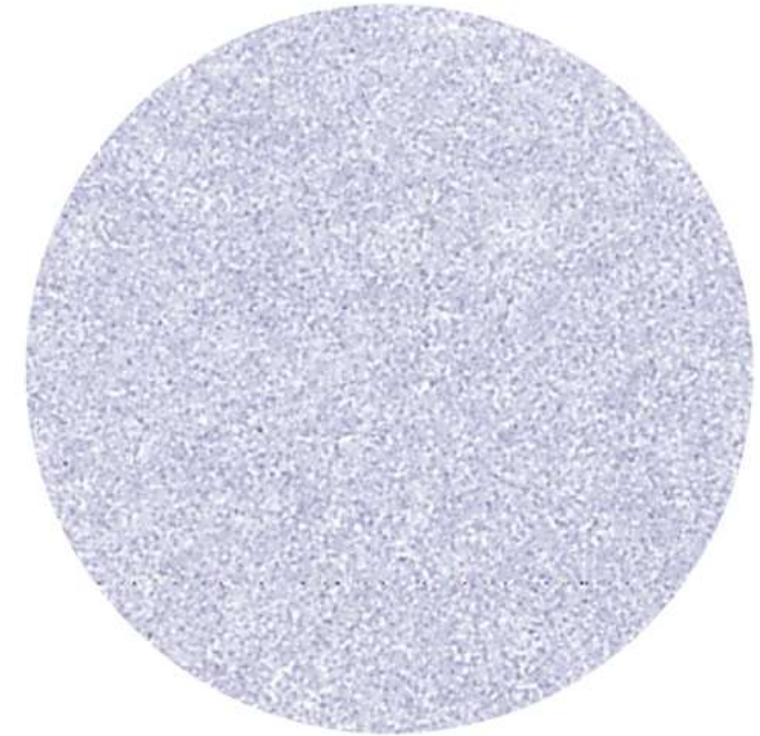


Grinding with SiC Papers

- I use a strong water flush to keep abrasive clean and sample cool (if sample with tolerate – if not Glycol)
- Will use more initial SiC papers if I see the entire surface has not received an initial grind
 - Can be issue with larger samples, or if sample plane not well aligned in mount
- I like adhesive papers because they stick better than ring retained clothes for me
- I clean head with water and paper towel between each grit size to prevent contamination

Polishing

- I use 1 μ m and 0.3 μ m Al₂O₃ as primary abrasive
 - I use water based suspensions
 - More economical than diamond abrasives
- I use Imperial cloth from Allied High Tech as primary polishing cloth
 - All purpose cloth
 - Low napped
 - Synthetic Rayon



Polishing with Al_2O_3

- For each abrasive size, I use 1 Imperial cloth for 10 minutes
- I run with 9 lbf and 130 RPM on the platen
 - A little less force and a little less pressure than with SiC papers
- I use contra rotation between the platen and the wheel
 - Removal rate is slower than with SiC papers
- Charge cloth with water, and then drip water through the run
- Liberally add abrasive during the run
- Clean head and platen with water after each abrasive

Other Polishing Cloths and Abrasives



Other Polishing Cloths and Abrasives

- This approach is a general approach
 - Usually I try this on most materials
- Will try different cloths and abrasives when necessary
 - If I'm not happy with my results or if I know sample is difficult
 - Hard materials
 - Soft materials
 - Multiphase materials (with different material removal rates)
 - Thin materials (don't want to polish through the sample)
 - Reactive materials (don't want sample to react with water, etc.)
- Will ask sample prep vendors or read website descriptions and recipes for ideas
 - I don't compare recipe results vs. standard results

Vibratory Final Polishing

- Final polish is typically done with vibratory polisher with colloidal silica
- Generally mounted sample is placed in weighted holder to run on cloth
- Use Imperial cloth (same as polishing)
- Will polish anywhere from 15 minutes to overnight, depending on sample and timeframe



Colloidal Silica

- Colloidal silica is a chemical-mechanical polishing solution
- It can be messy, and there is a 0.04 μm version to help there
- A water-free 0.05 μm version available for water-sensitive materials
- Generally we use 0.02 μm , as it should give finest polish



Vibratory Final Polishing

- The longer the polishing time, the better the surface but also the greater chance of differential polishing rates with different materials
- 2-4 hours typical
- Keep time constant for samples you want to compare
- Keep the cloth clean with cover to prevent the solution from drying and crystallizing to prolong lifetime
- Be aware of possible contamination from earlier samples
- Cleaning platen and making sure cloth is flat helps ensure the sample will continue to move

Mounting Samples for SEM

- We generally mount samples to pin stubs for SEM work
- Hot glue gun provides fast and strong adhesion with vacuum compatibility
- For non-mounted sample, will sometimes use silver paint
- Silver paint used to provide grounding path
 - Let silver paint dry



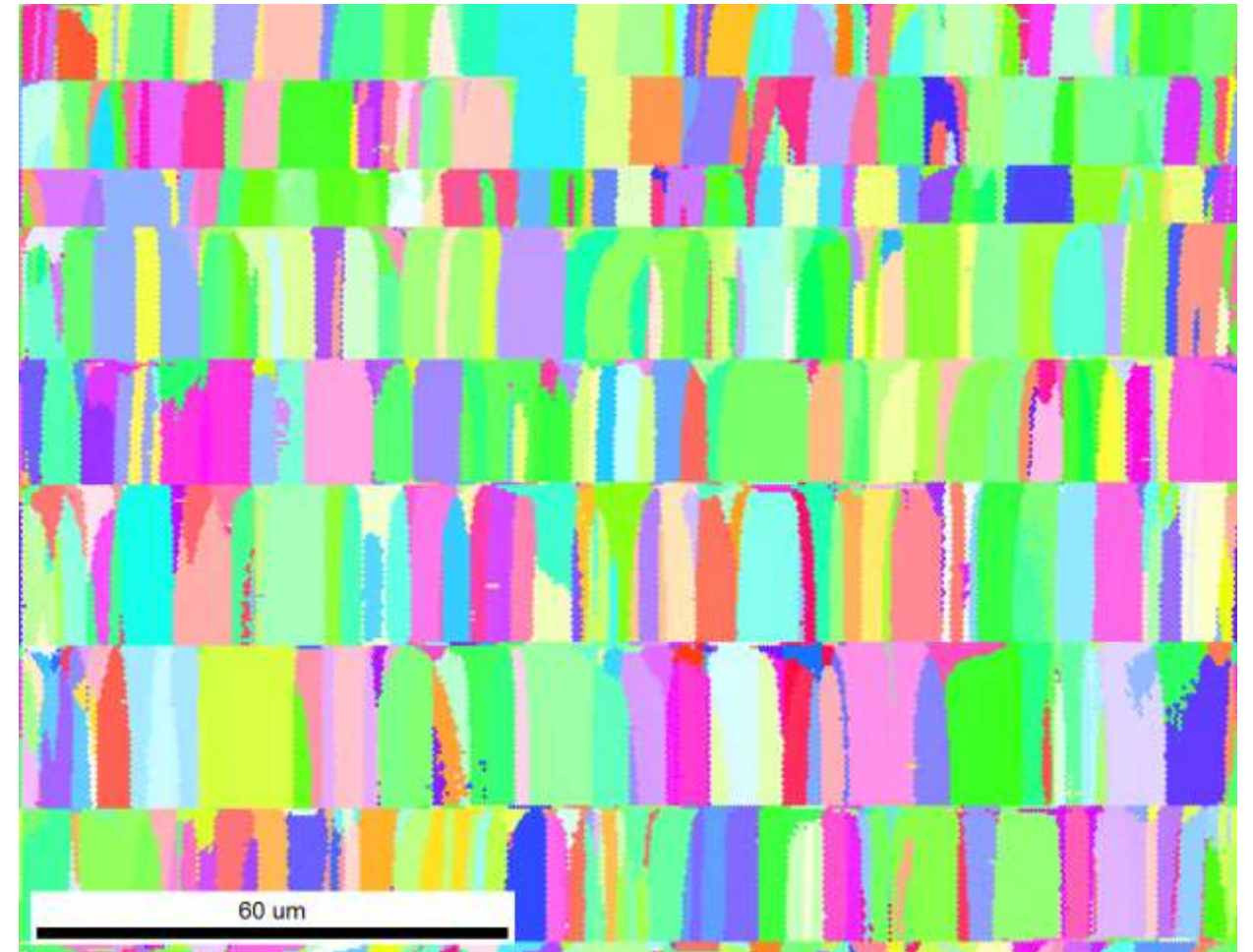
Carbon Tape

- For mounting samples, I avoid carbon tape
- Carbon tape can creep over time, and cause the sample to shift when tilted for EBSD work
- Carbon tape can be used to provide a ground path.
- I typically use Copper tape for enhanced conductivity



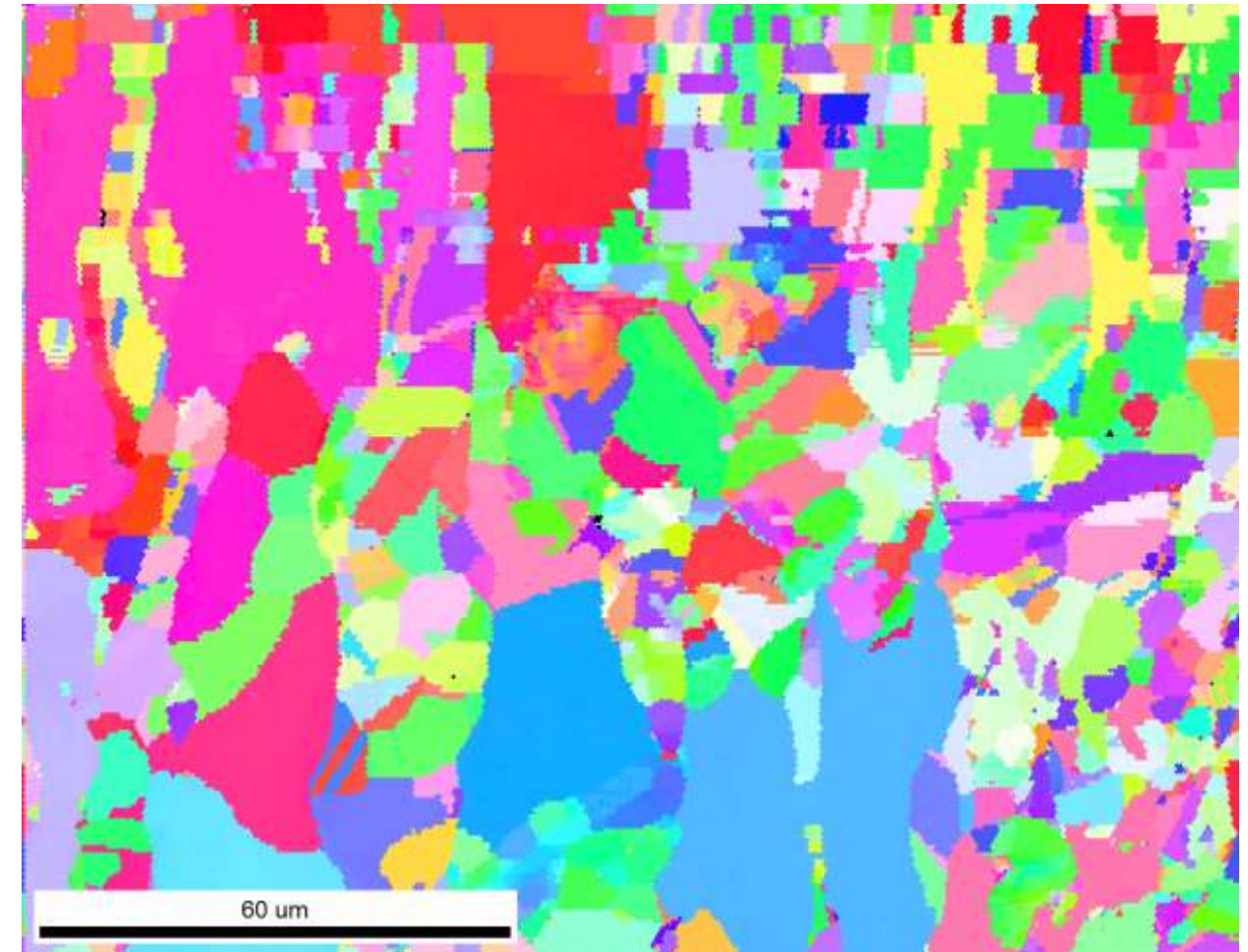
Grounding the Sample

- It's important to ground the sample to prevent charging effects
- Generally I will paint a path from sample to stub with silver paint
 - Conductive mount not as conductive as I would hope
- Sometimes I will run a piece of copper tape from sample to stage
- Can check with voltmeter



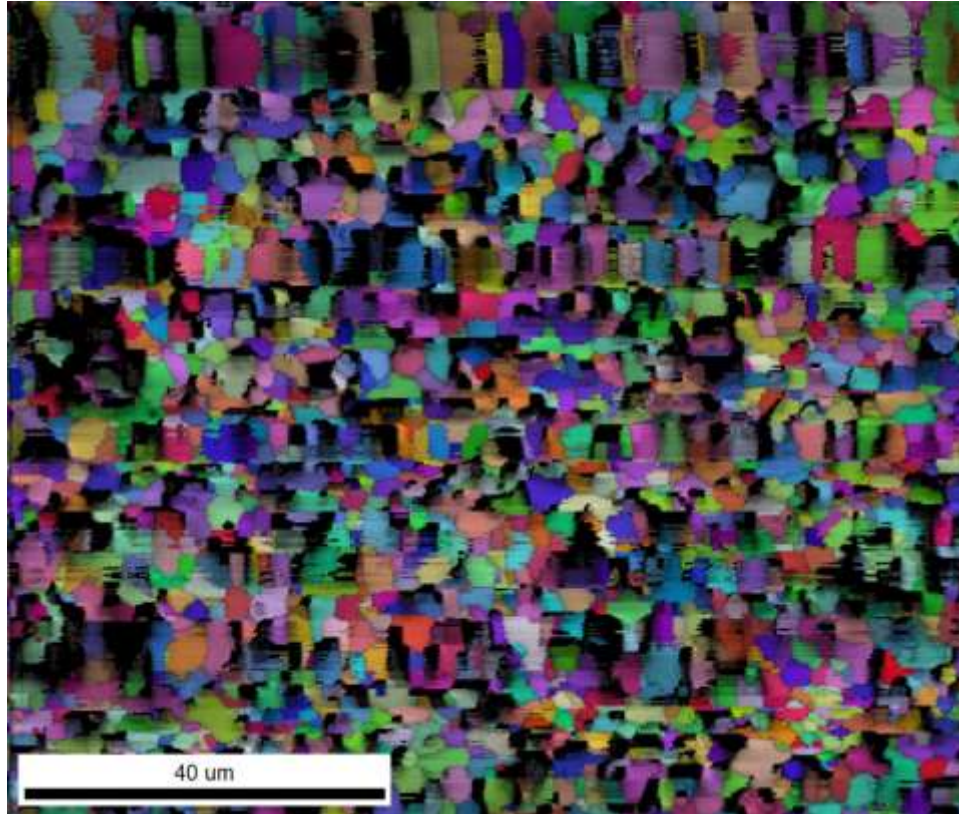
Grounding the Sample

- Carbon coating can improve conductivity
 - I like using a thickness meter for consistency and reproducibility
- Low vacuum SEM
 - You don't need much to reduce effects on tilted sample
- Image sample (semiconductor) before mapping to reach a steady-state condition

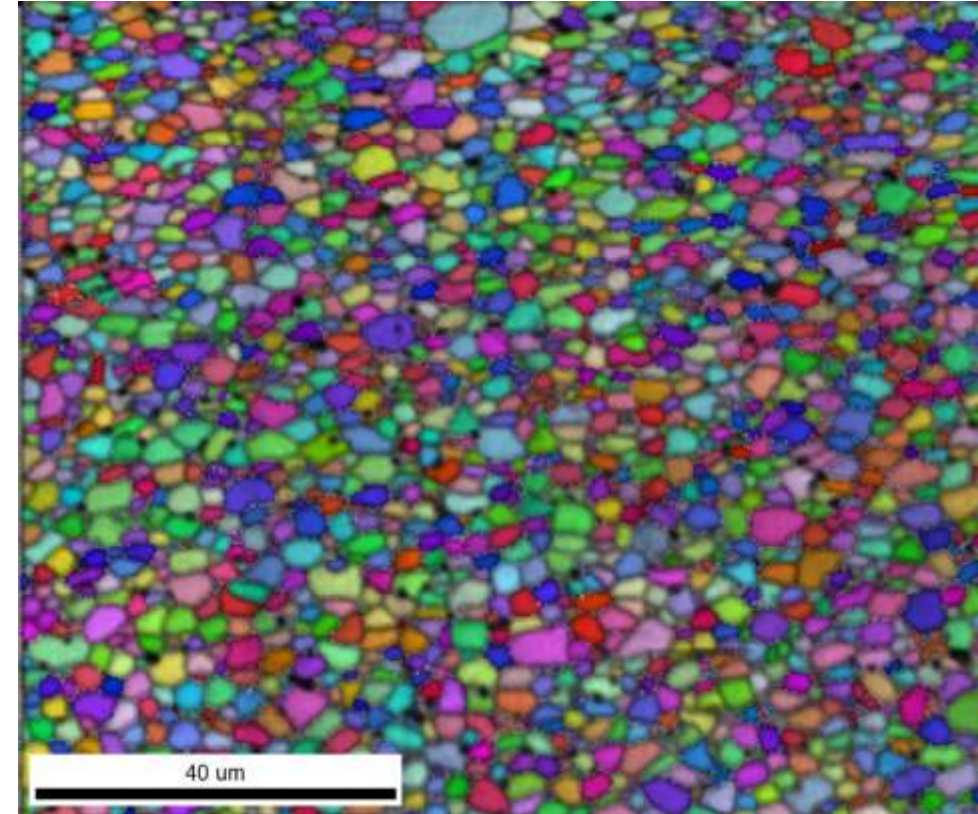


NPAR on Non-Conductive Ceramic

20kV 5nA Beam Current



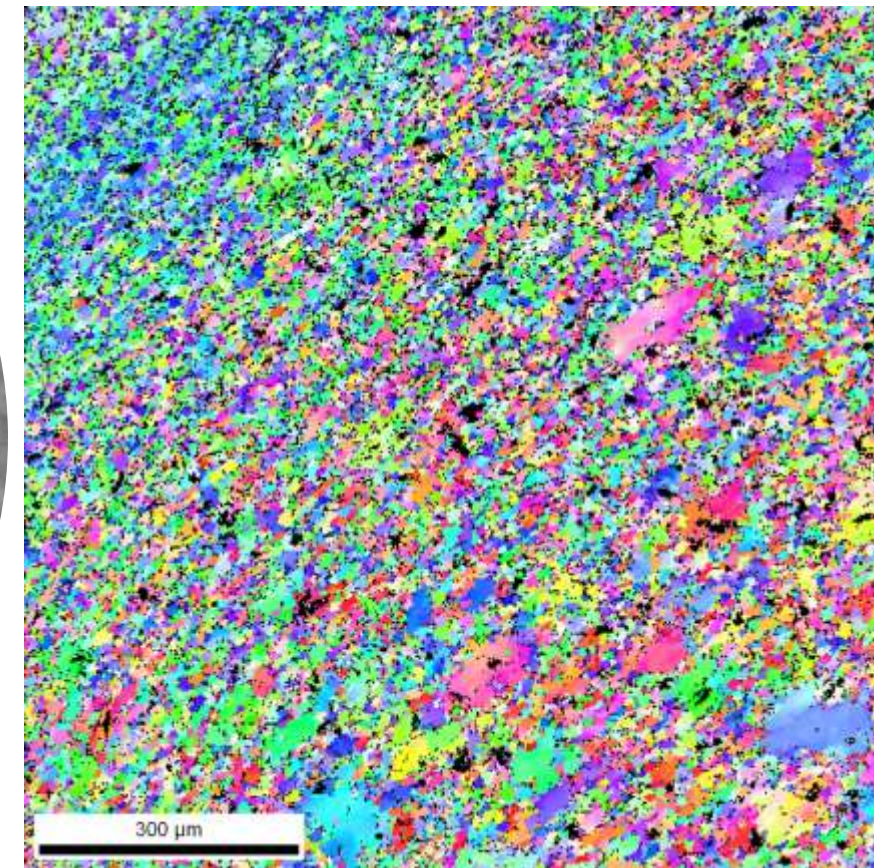
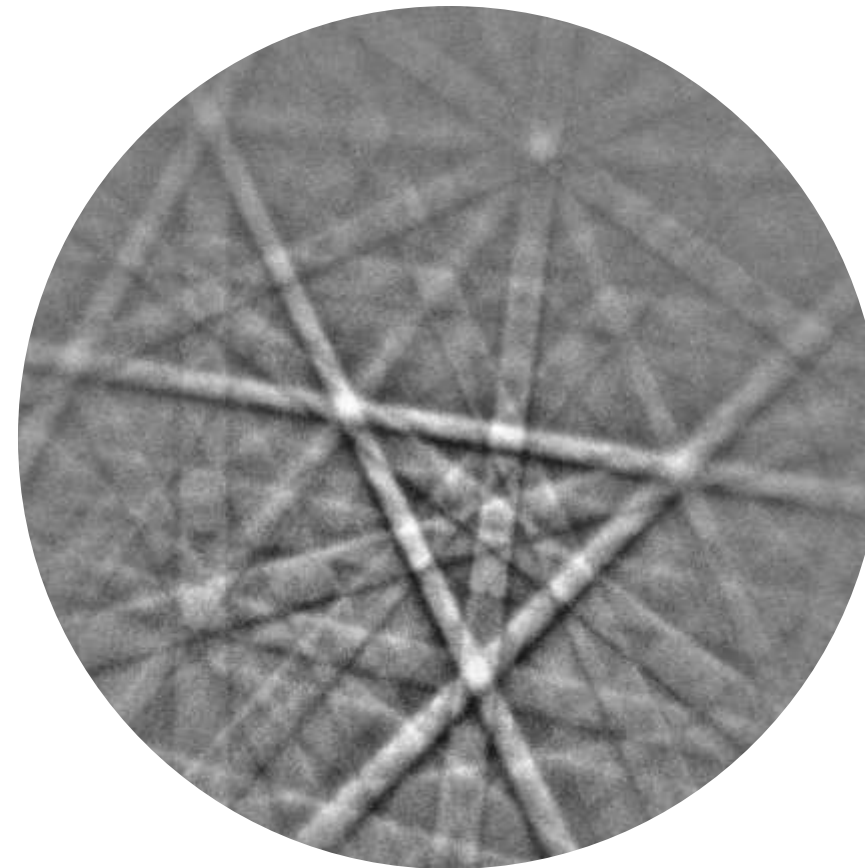
12kV 1.5nA Beam Current - NPAR



- Reducing electron dose (both energy and current) can reduce charging effects. NPAR can maintain indexing speeds.

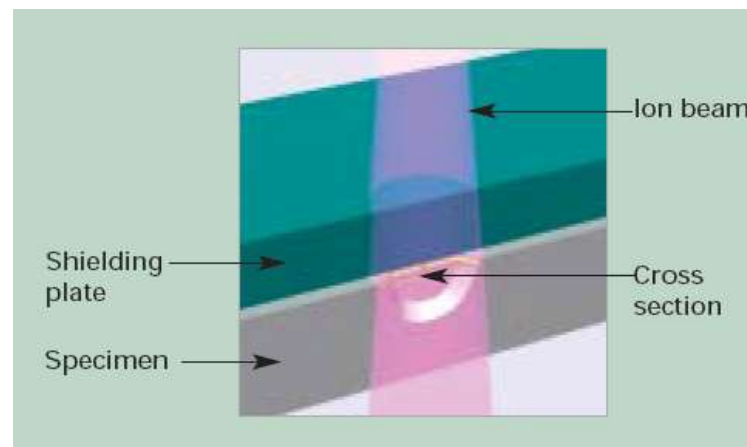
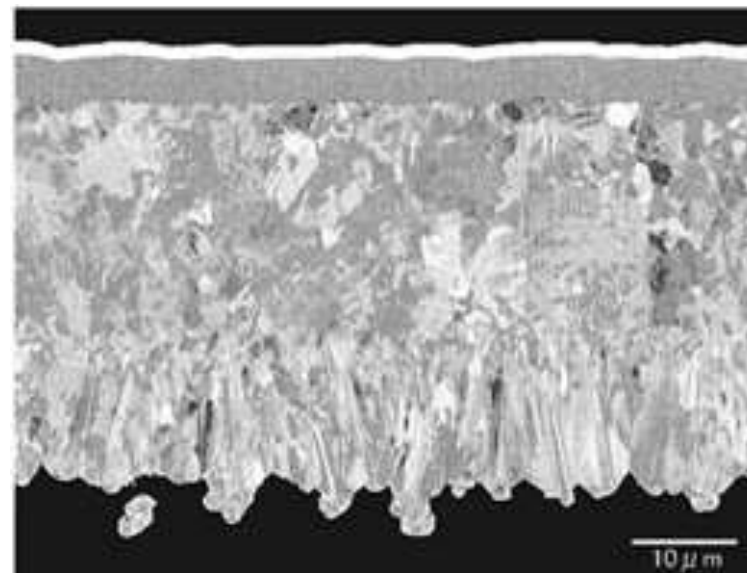
Ion Etching for “Difficult” Materials

- I have used broad ion beam polishing to prepare materials like magnesium and zirconium
 - Can remove oxide layers easily
- Control angle and energy of incident ion beam

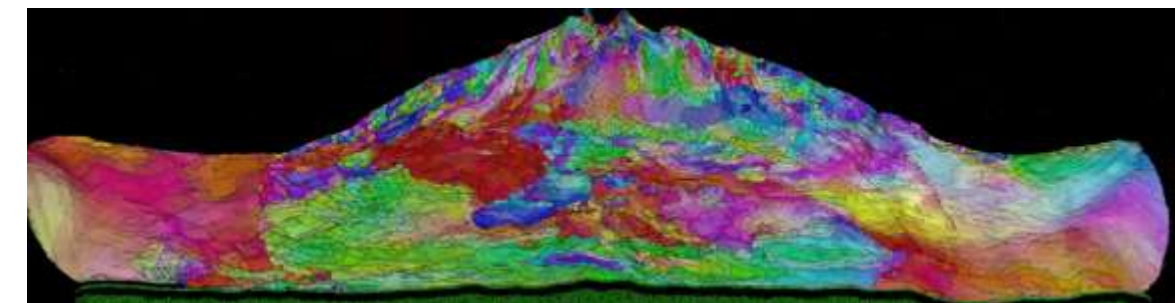
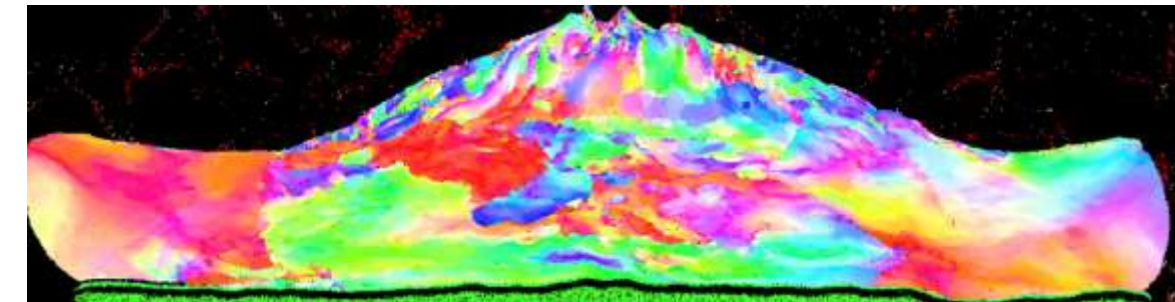
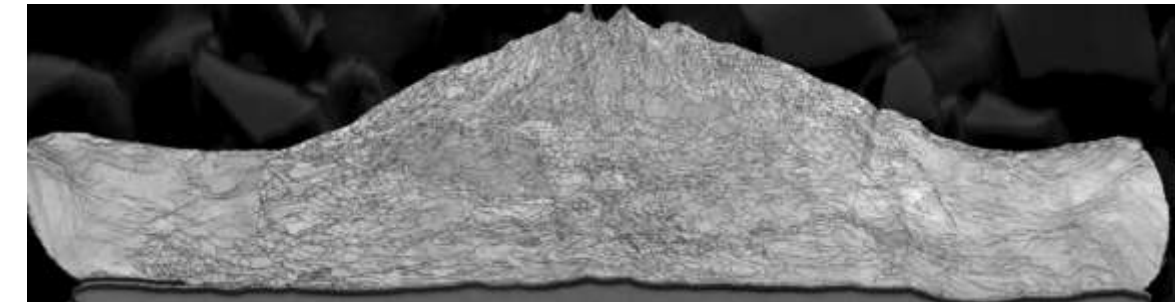


Cross-Sectioning Ion Beam Polishers

- I haven't used a ion CSP, but they produce nice EBSD patterns
- Very little ion damage due to beam geometry
- Some limitation in ion polished area

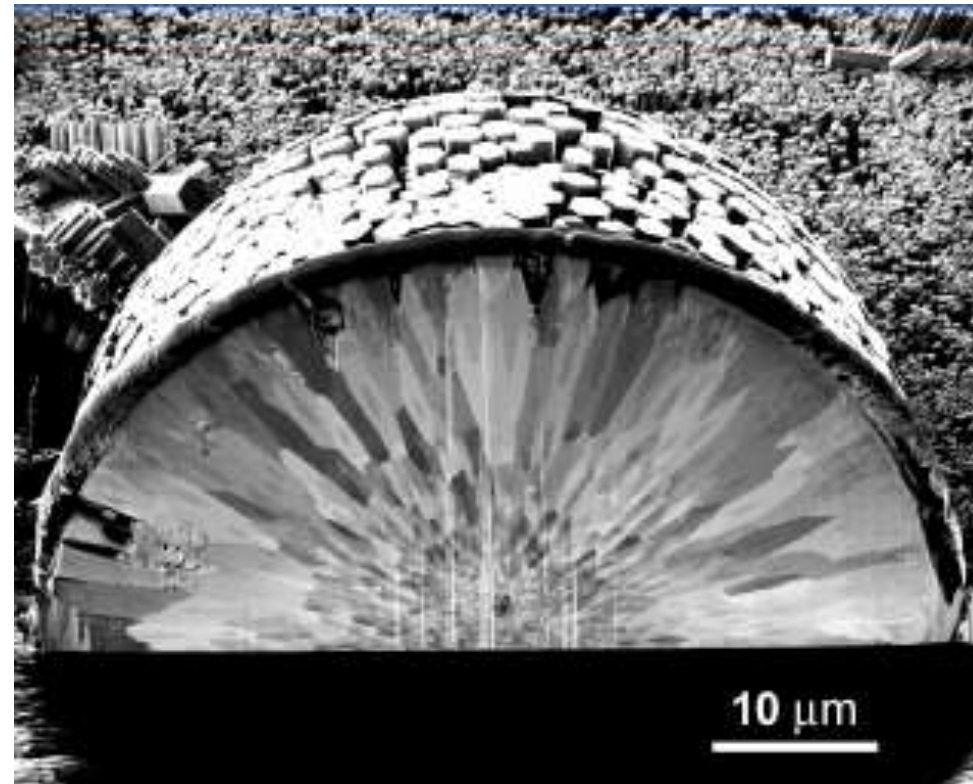


Source: JEOL

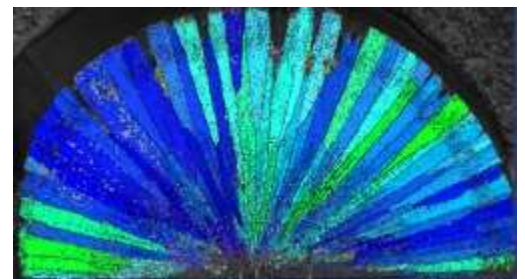
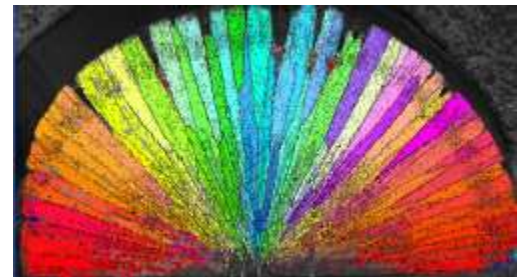
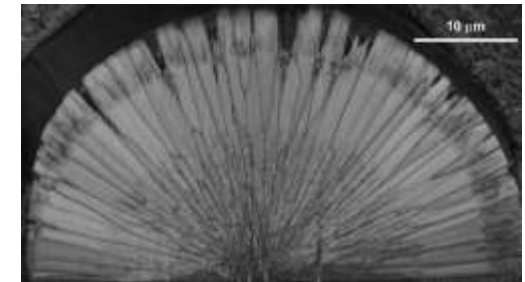


Focused Ion Beam

- FIB enables site-specific EBSD preparation on very small scale



FIB enables site-specific EBSD preparation on a very small scale that would otherwise be impractical.

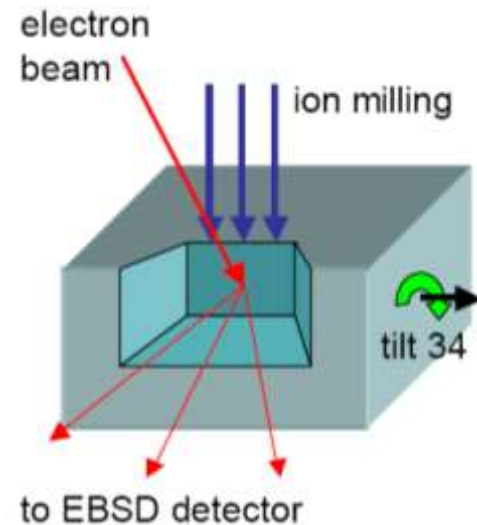


Data courtesy of Joe Michael – Sandia National Laboratory

Focused Ion Beam

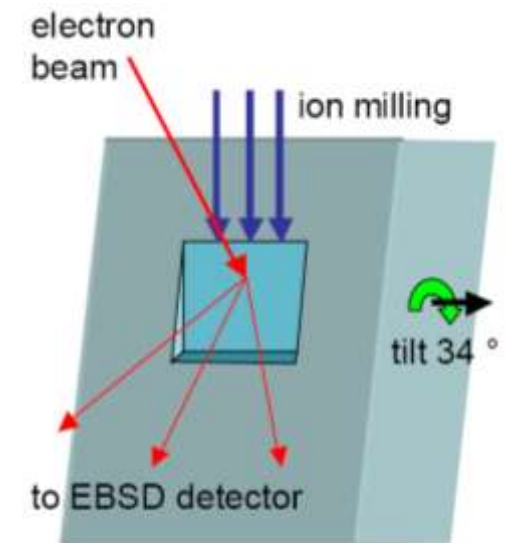
- Ion beam can remove material and leave an EBSD-quality surface
- Can control energy and incident angle of ion beam
- Can use Ga or Xe ion beams
 - Xe can prepare larger areas
- Can prepare samples in-situ
 - Used for Atom Probe Assist samples

milling strategy:
grazing-incidence
edge-milling



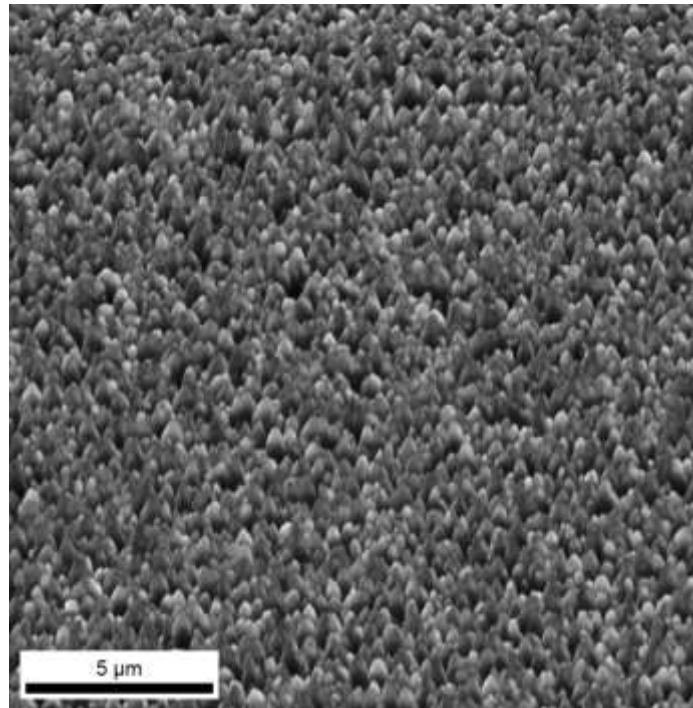
feature has to be at
edge

milling strategy:
low-incidence
surface-milling

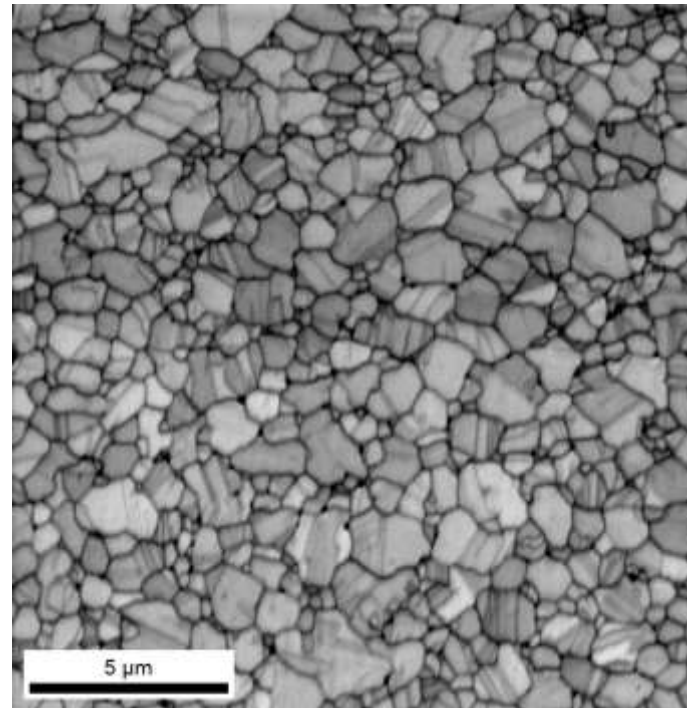


large milling areas
required to avoid
shadowing of EBSD

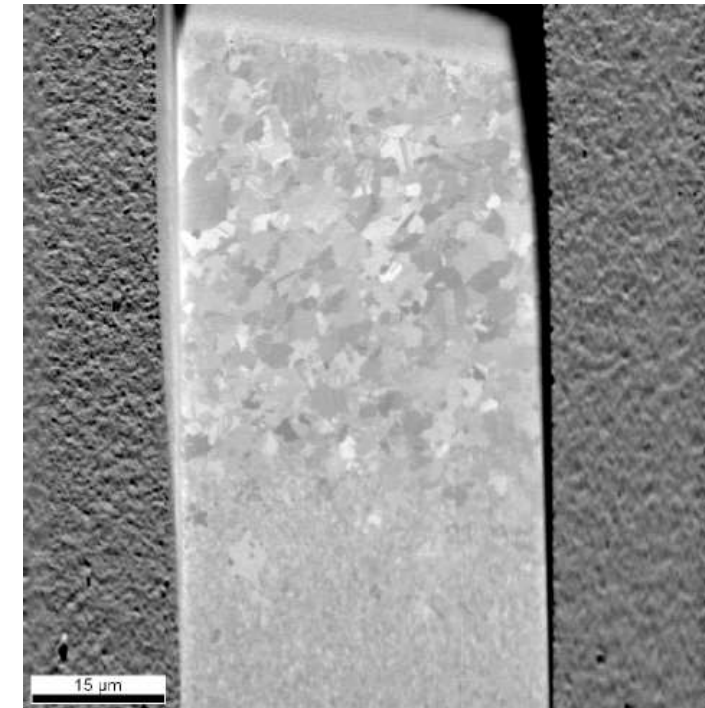
Sample Preparation for EBSD



As-Deposited CdCl₂
Treated



FIB Prepared CdCl₂
Treated

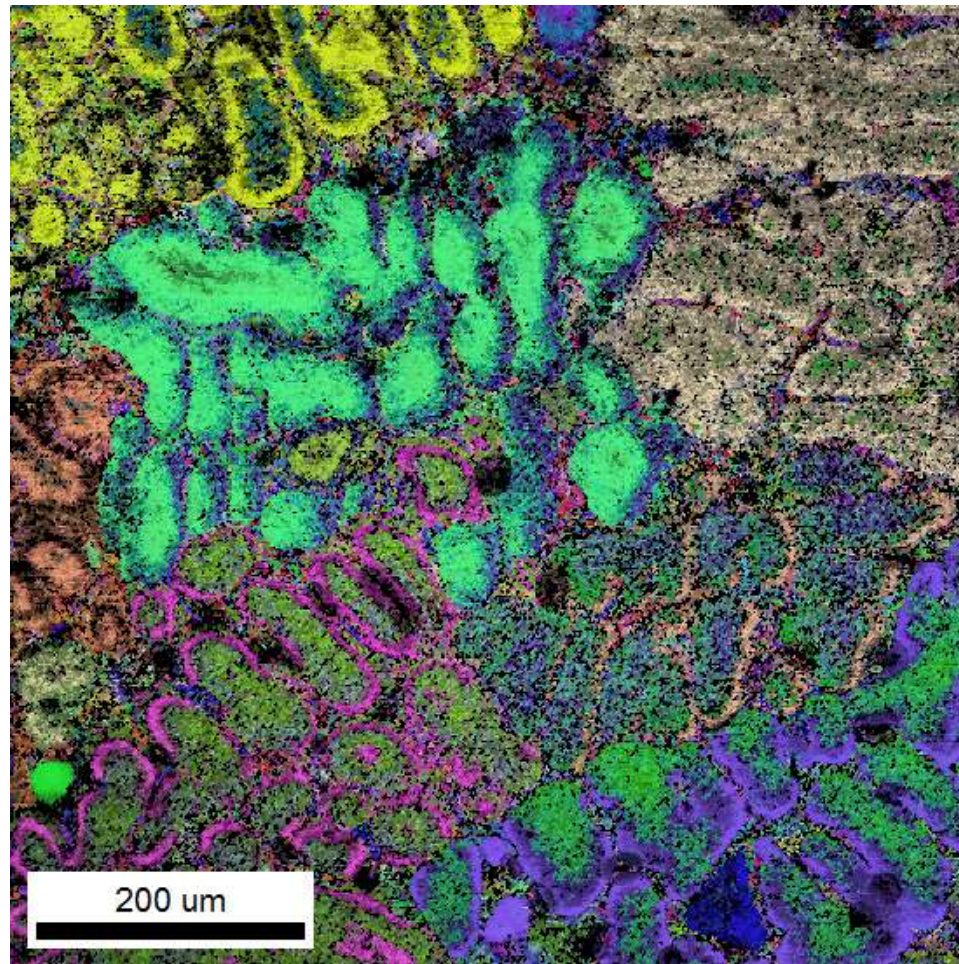


FSD Orientation Contrast
Image

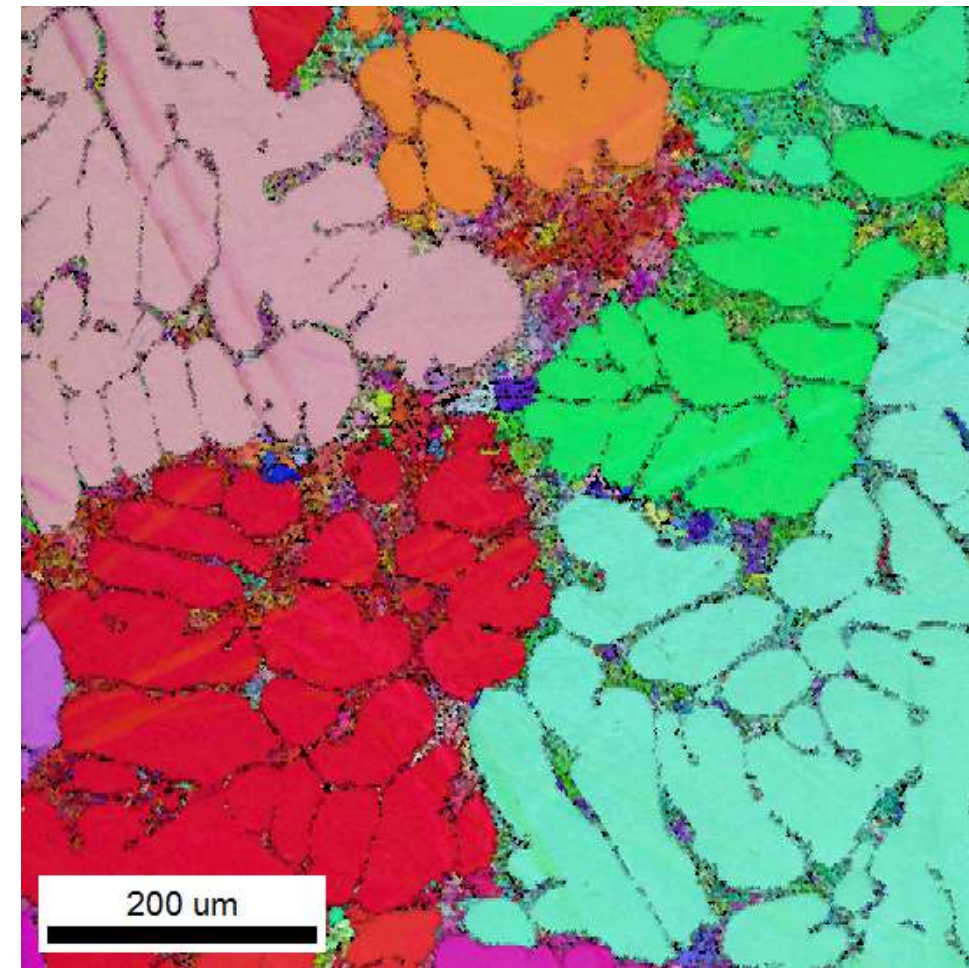
30kV 1nA Ga⁺ FIB (FEI Quanta 3D) used with glancing angle (1.5°) to cut surface for EBSD collection

Ion Beam Improving on Mechanical Polish

- In some cases (often multi-phase), ion beam polishing improves EBSD results relative to mechanical polishing



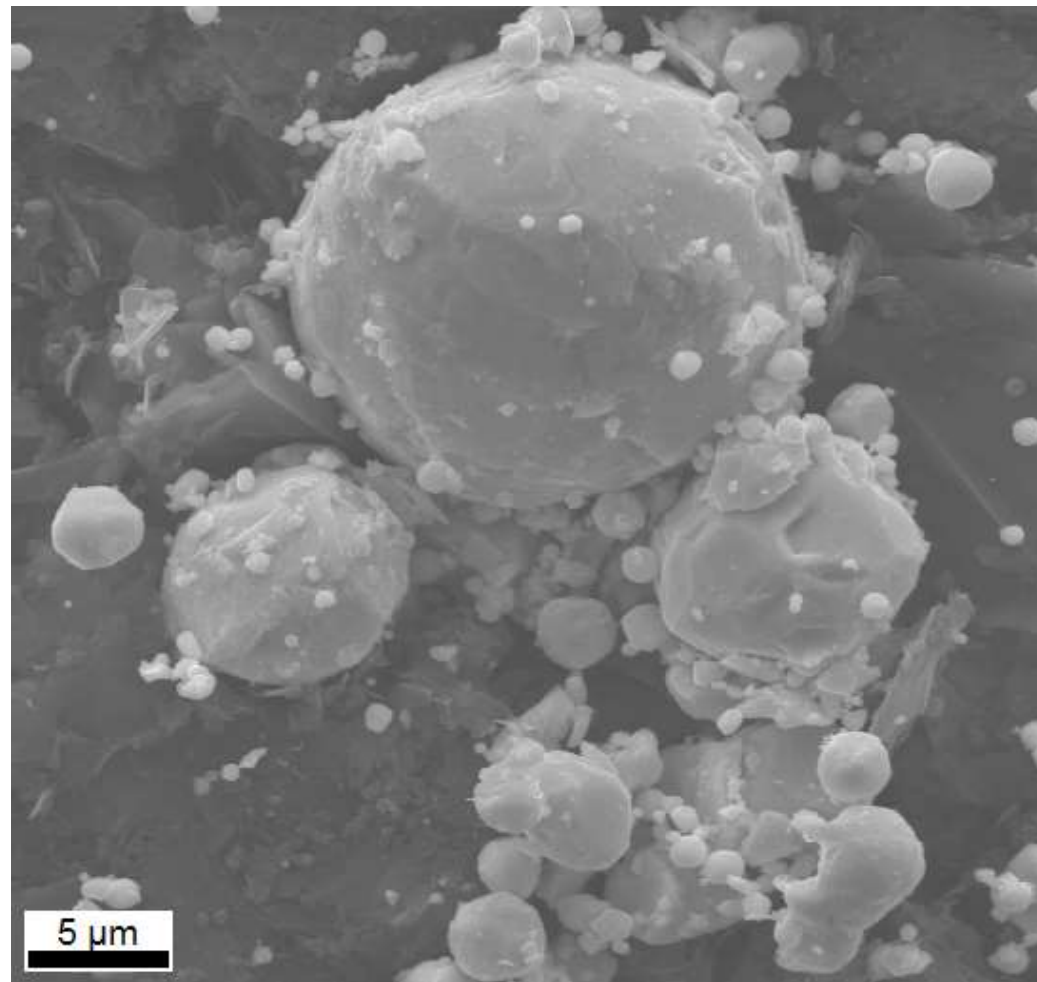
Mechanical Polishing
82.5% ISR



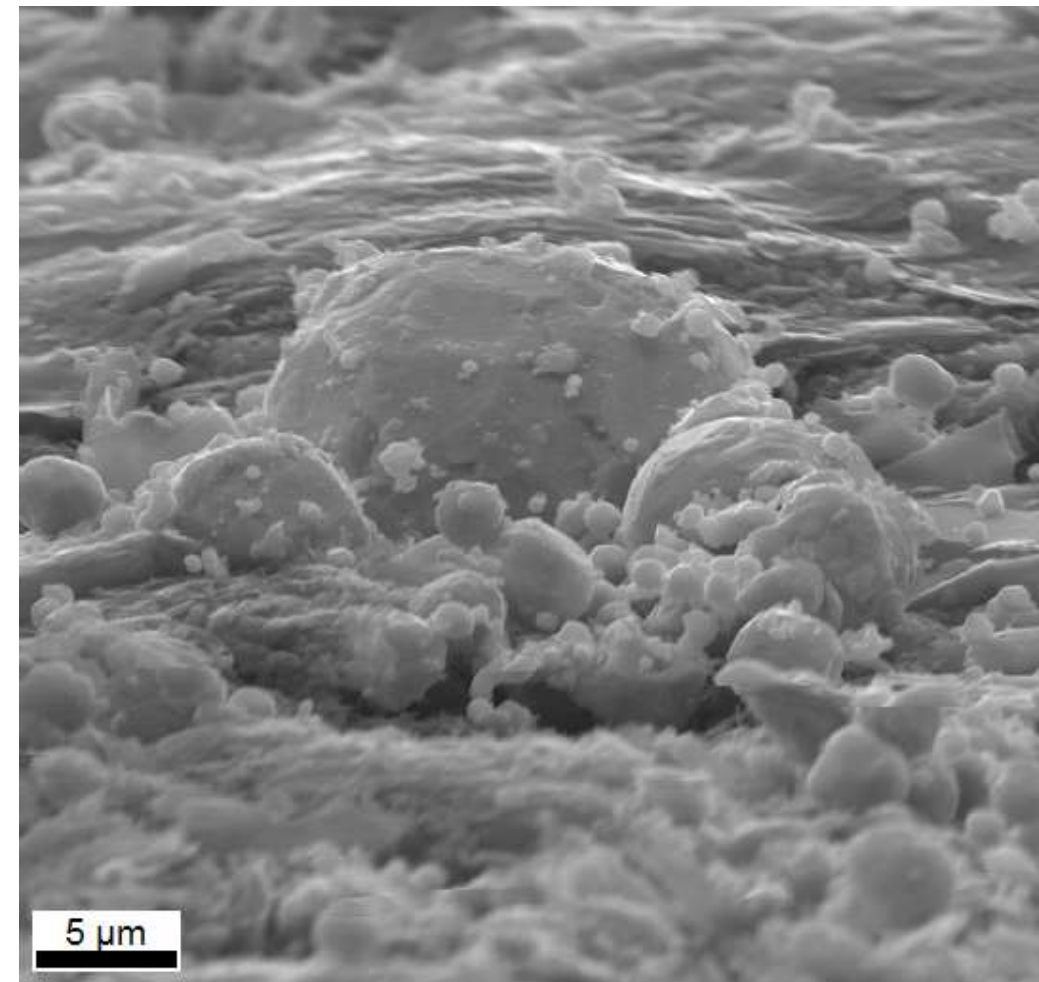
Ion Polishing
98.4% ISR

Nanostructured Bi_2Te_3 Powder

0° Tilt



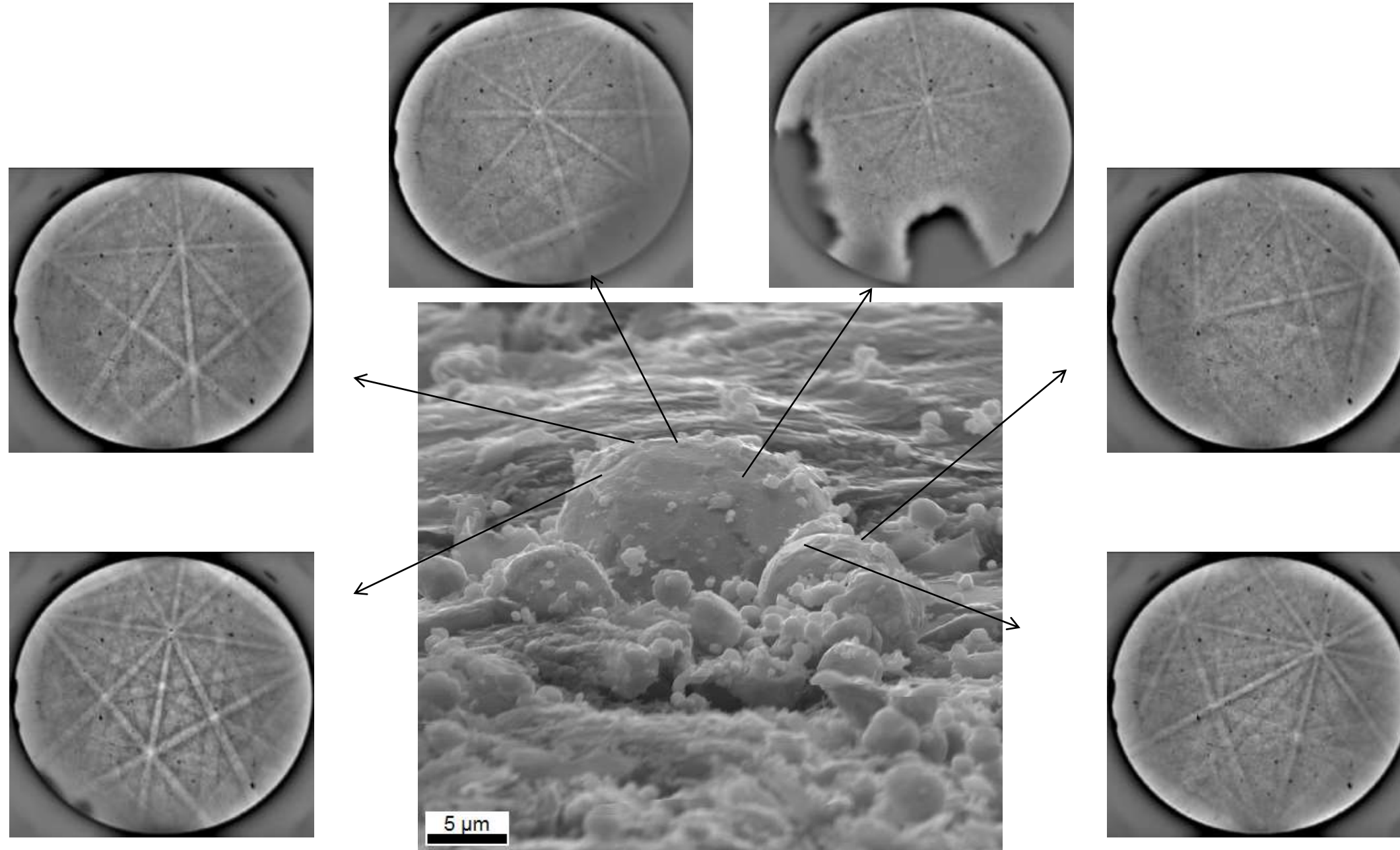
75° Tilt



Nanostructured Bi_2Te_3 powder produced by supersonic gas atomization as a method to reduce grain size

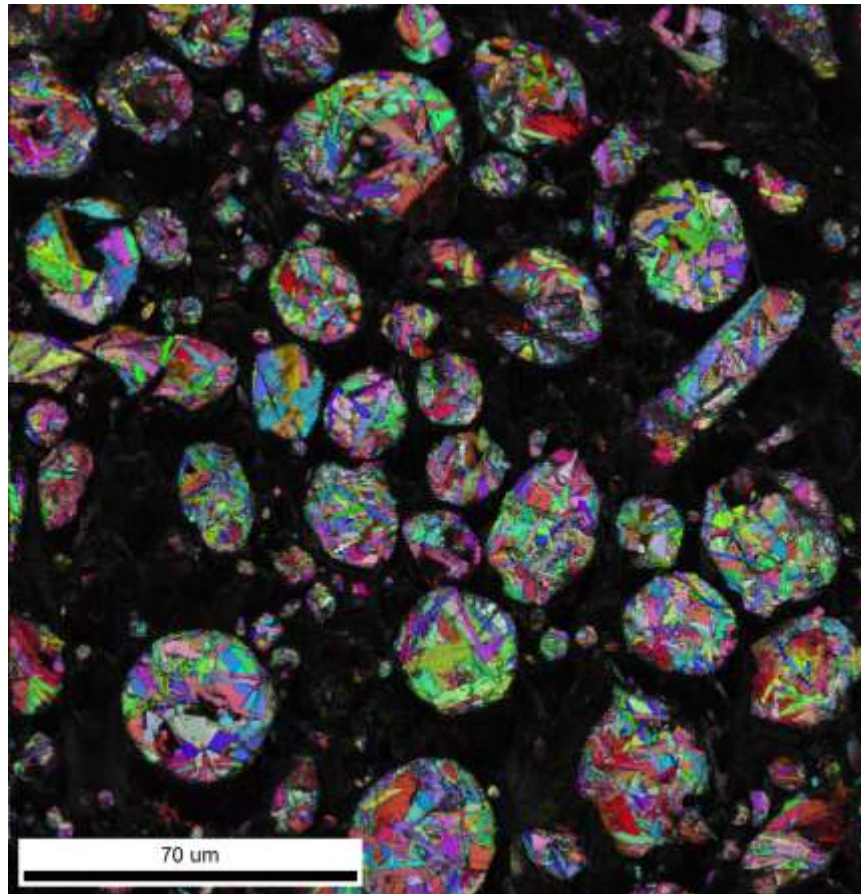
Samples courtesy of and in collaboration with TXL Group

EBSD Patterns from Nanostructured Powder

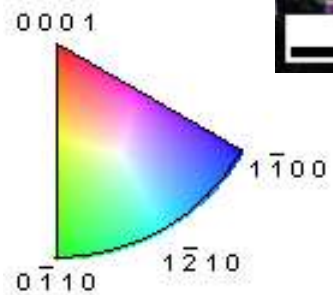
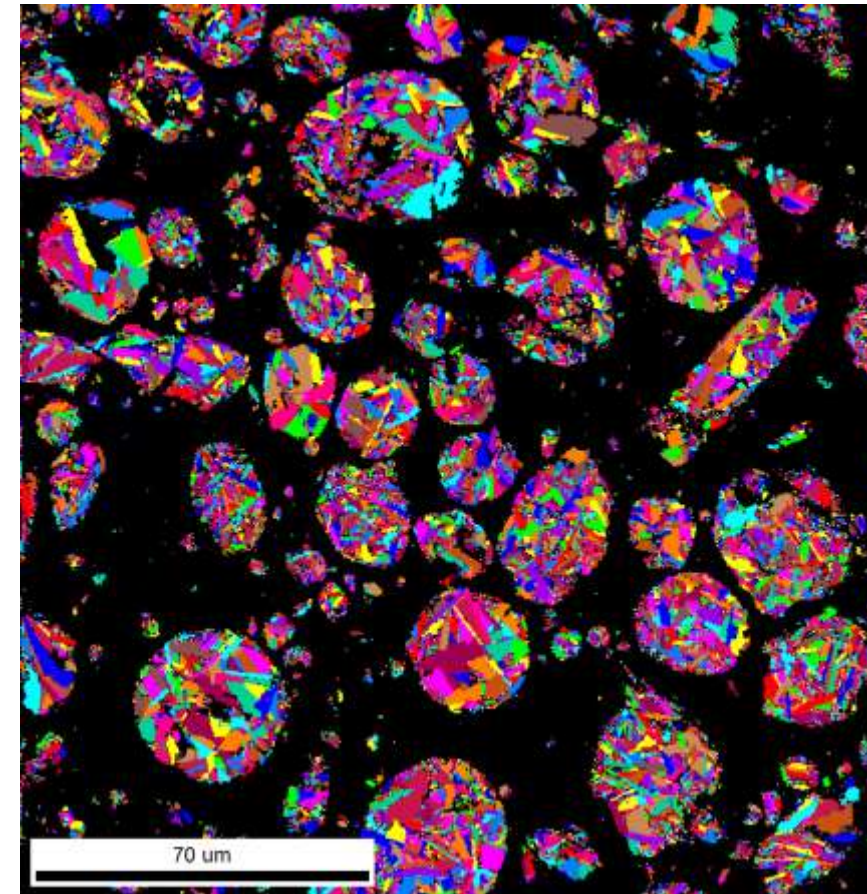


EBSD Maps from Polished Powder

Orientation Map



Grain Map



With 200nm EBSD step size, grain size \approx 850nm

With 50nm EBSD step size, grain size \approx 200nm

Summary

- Sample preparation is important in order to obtain quality, representative EBSD patterns
- There are many different ways to prepare EBSD samples. For each, the goal is the same
- At EDAX Draper, mechanical polishing is the primary method used to prepare samples
- Thank you for your attention. Questions?

EDAX[®]



Smart Insight

AMETEK[®]

MATERIALS ANALYSIS DIVISION



[edax.com](https://www.edax.com)